



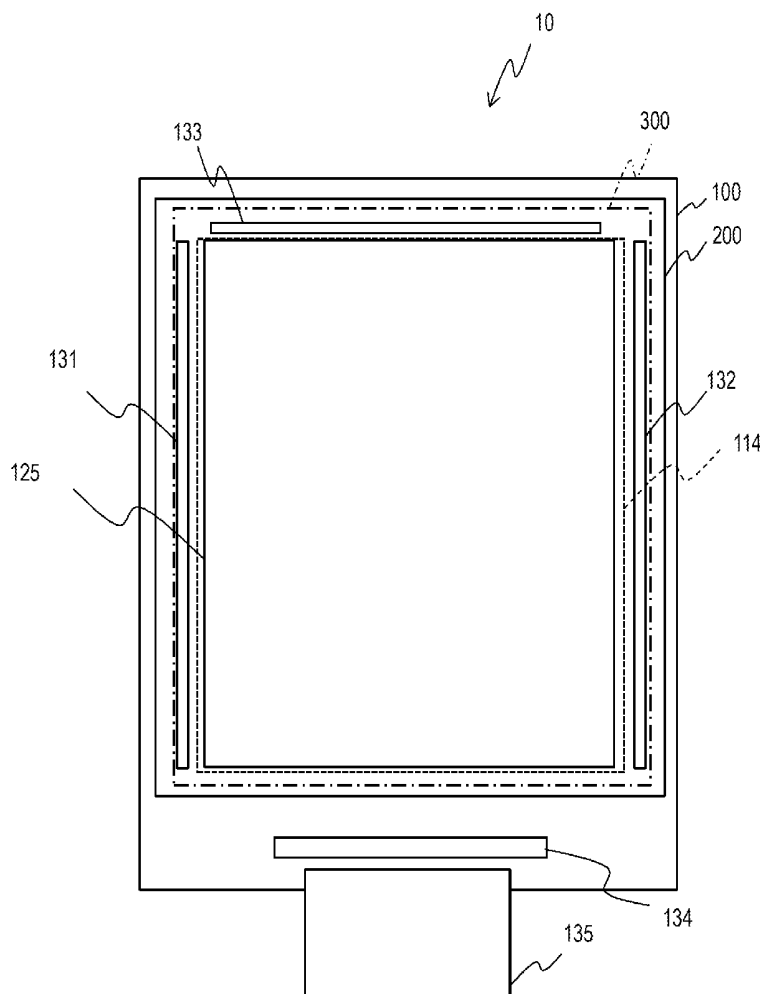
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MATSUEDA et al.(10) **Pub. No.: US 2019/0131589 A1**(43) **Pub. Date: May 2, 2019**(54) **OLED DISPLAY DEVICE, MASK, AND
METHOD OF MANUFACTURING OLED
DISPLAY DEVICE**(52) **U.S. Cl.**CPC *H01L 51/56* (2013.01); *H01L 27/3246*
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C23C 14/042 (2013.01); *H01L 51/524*
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Kenichi TAKATORI, Kanagawa (JP)(21) Appl. No.: **16/173,176**(22) Filed: **Oct. 29, 2018**(30) **Foreign Application Priority Data**

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H01L 27/32 (2006.01)
H01L 51/52 (2006.01)
G09G 3/3225 (2006.01)
C23C 14/04 (2006.01)(57) **ABSTRACT**

Distances between lines passing through the centroids of pixels in each of pixel rows are uniform. In each pair consisting of two adjacent pixel rows, each pixel of the first color in first pixel row of the pair of the two pixel rows is located at the center in the first direction between pixels of the first color adjacent to each other in a second pixel row of the pair of the two pixel rows. The shortest distance between perimeters of a first pixel and a second pixel of the same color which is closest to the first pixel in an adjacent pixel row is a distance between a point where a line connecting the centroid of the first pixel and the centroid of the second pixel intersects with opposed sides of the first pixel and the second pixel.



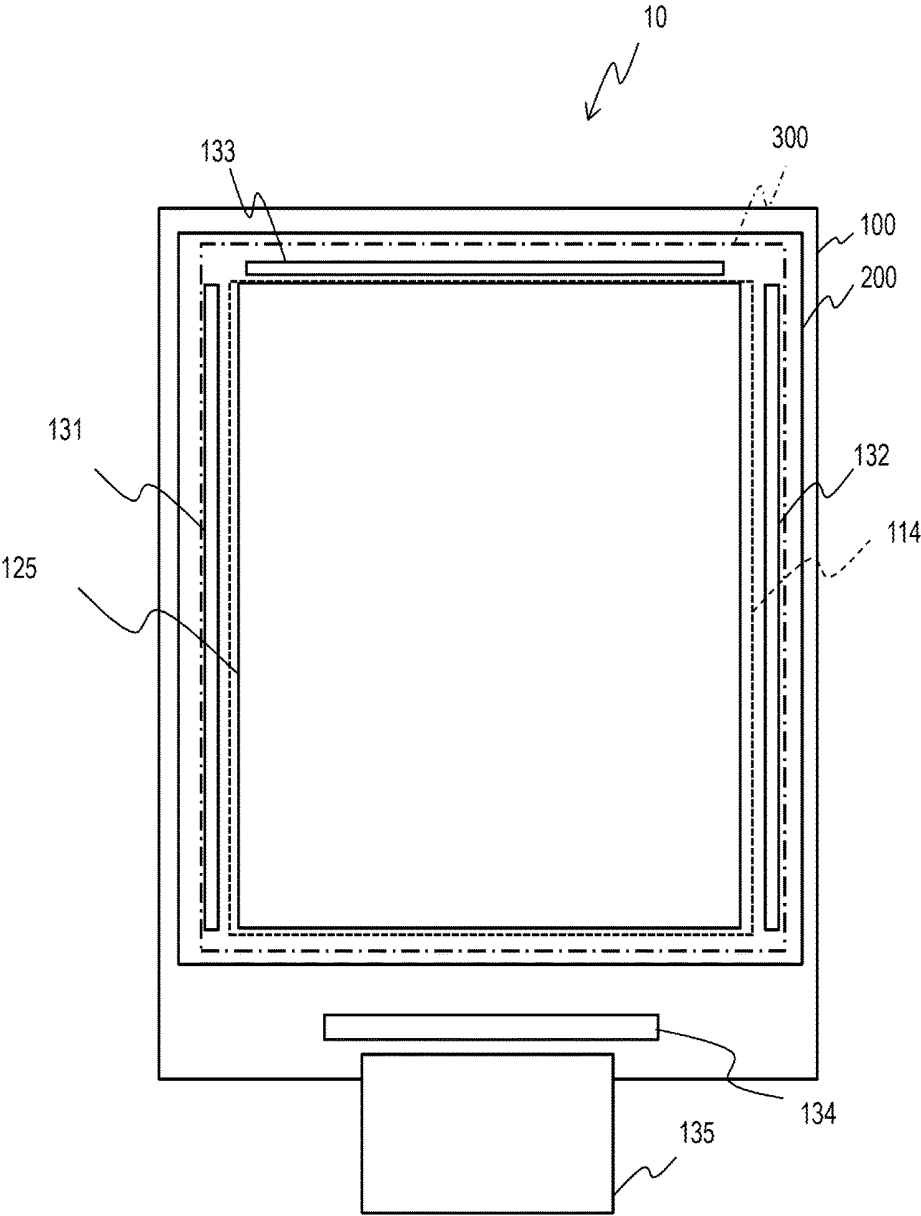


FIG. 1

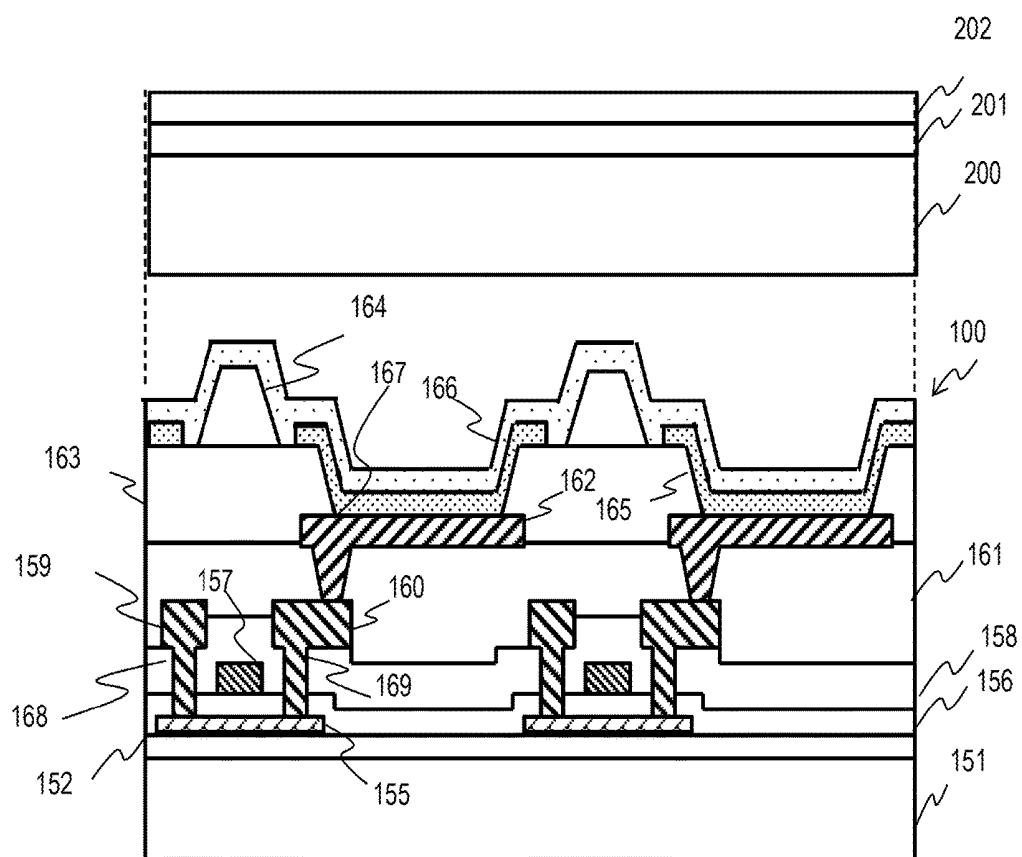


FIG. 2

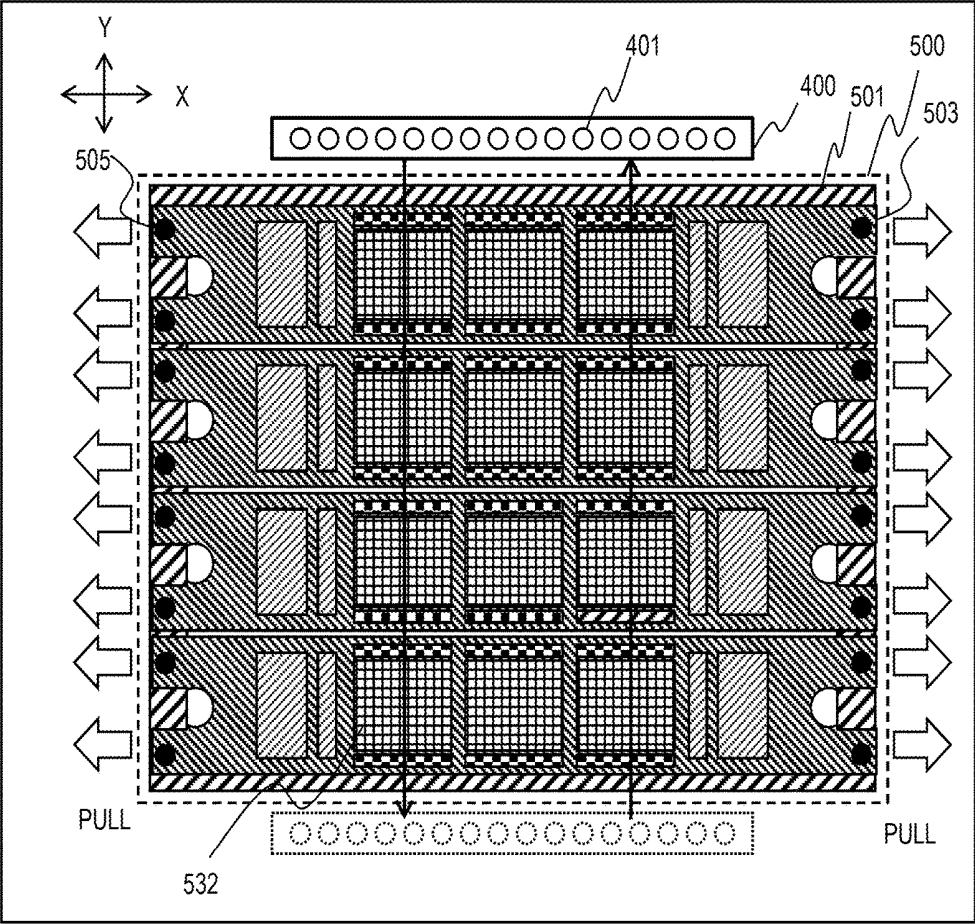


FIG. 3A

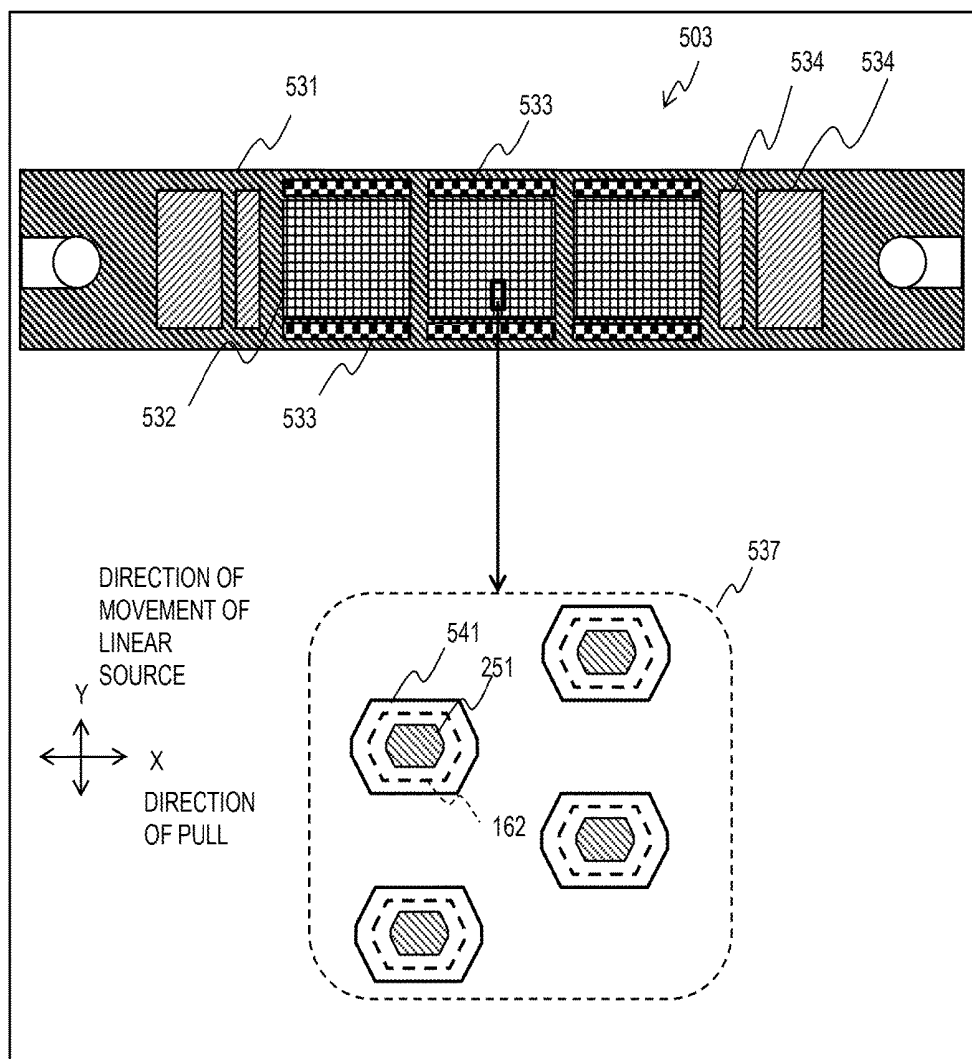


FIG. 3B

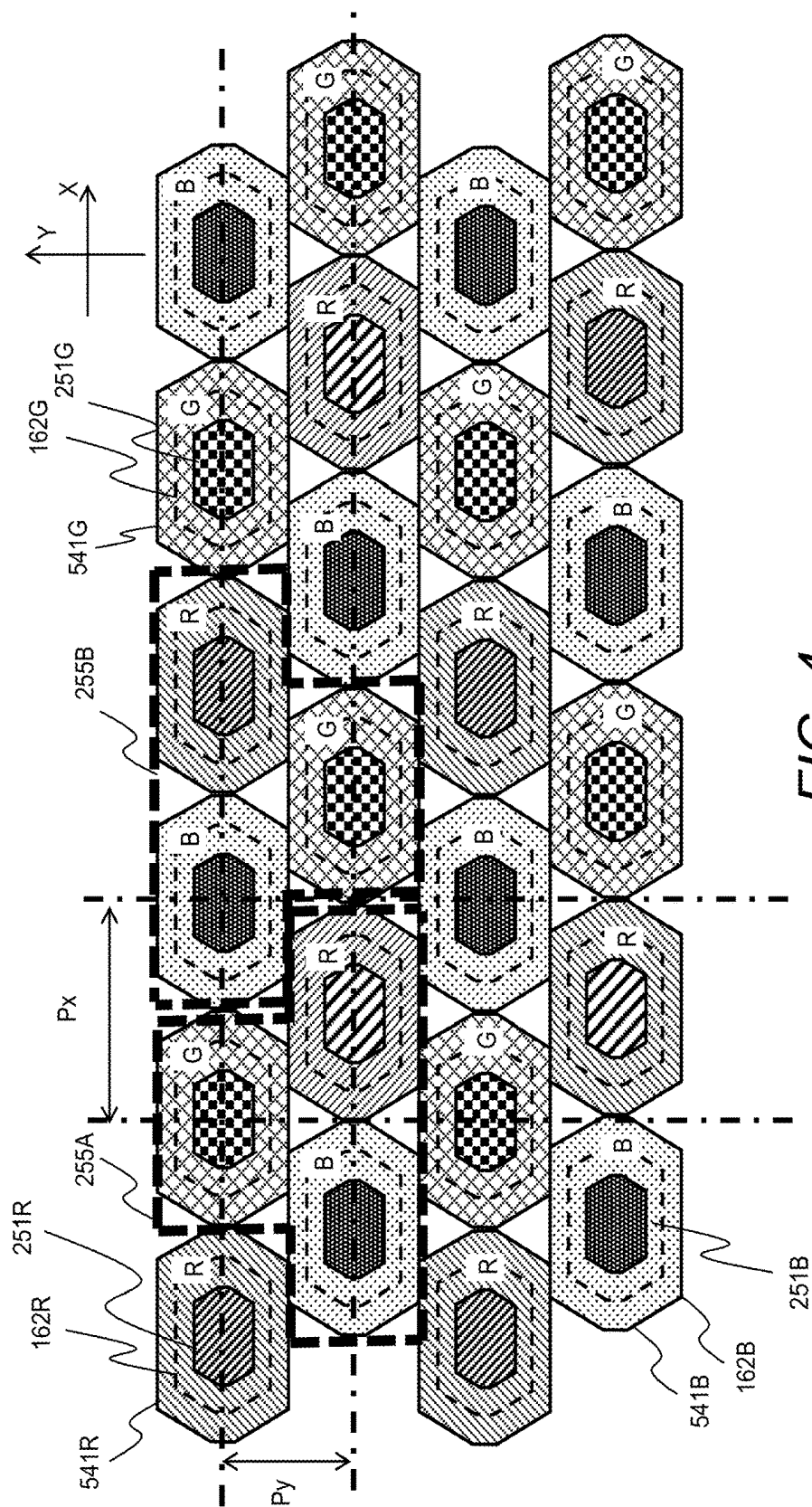


FIG. 4

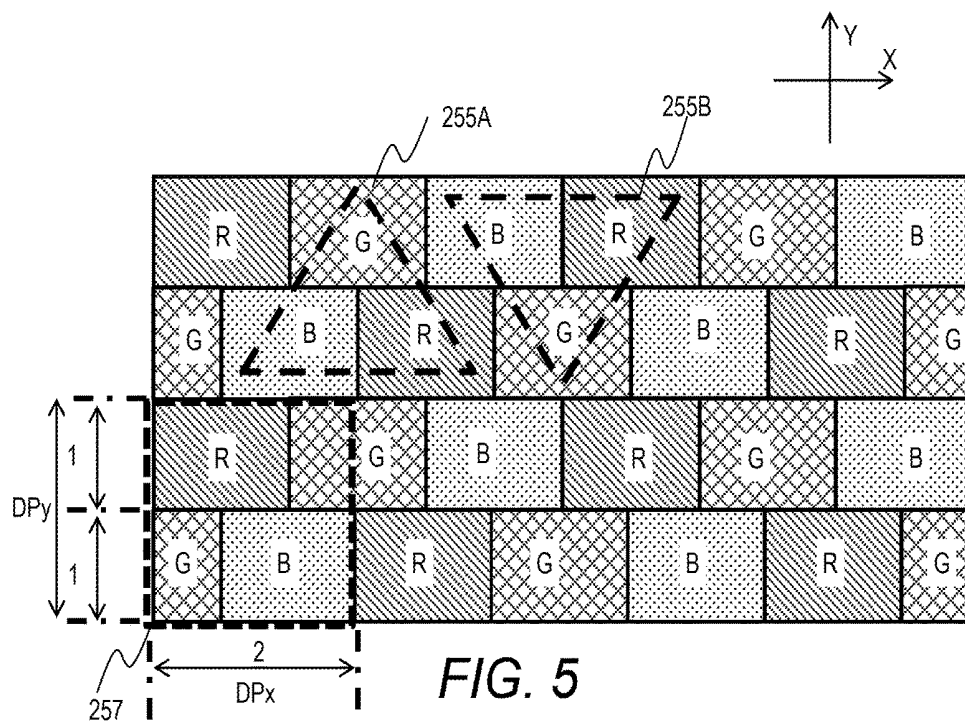


FIG. 5

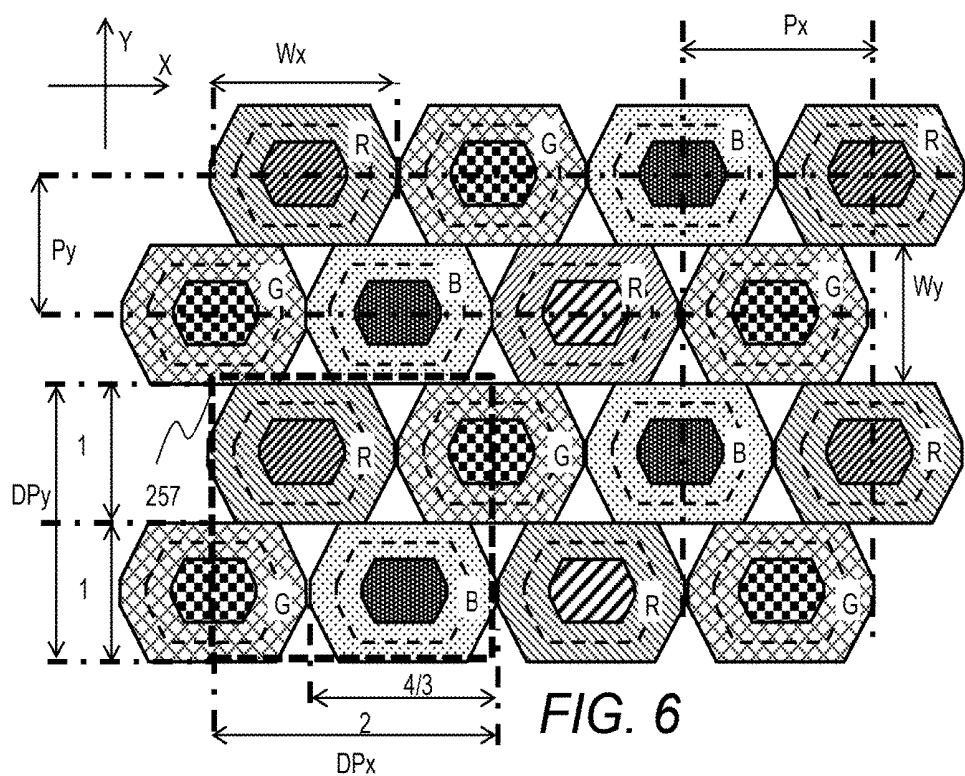


FIG. 6

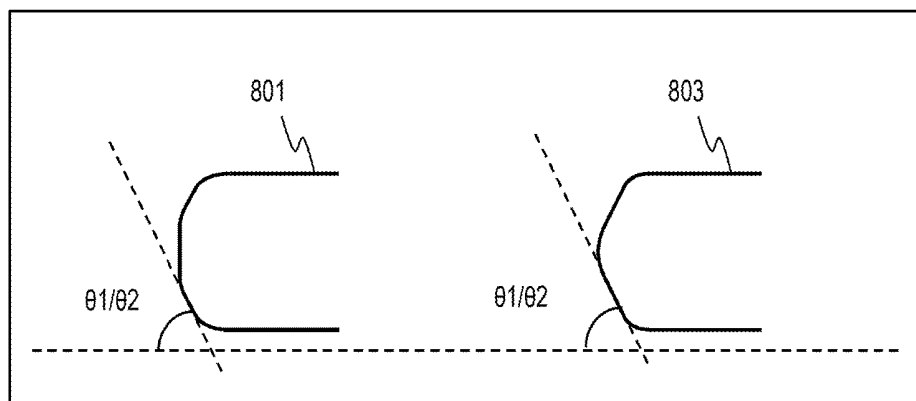
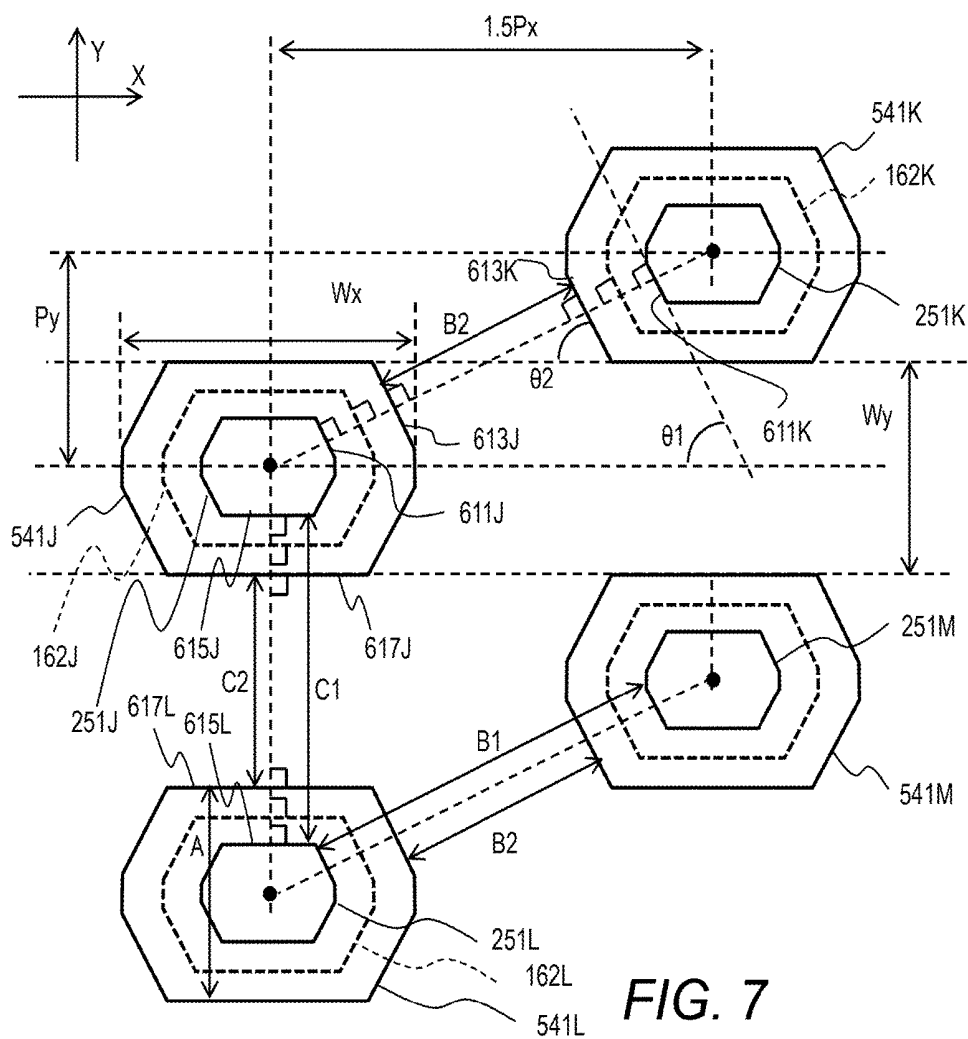


FIG. 8

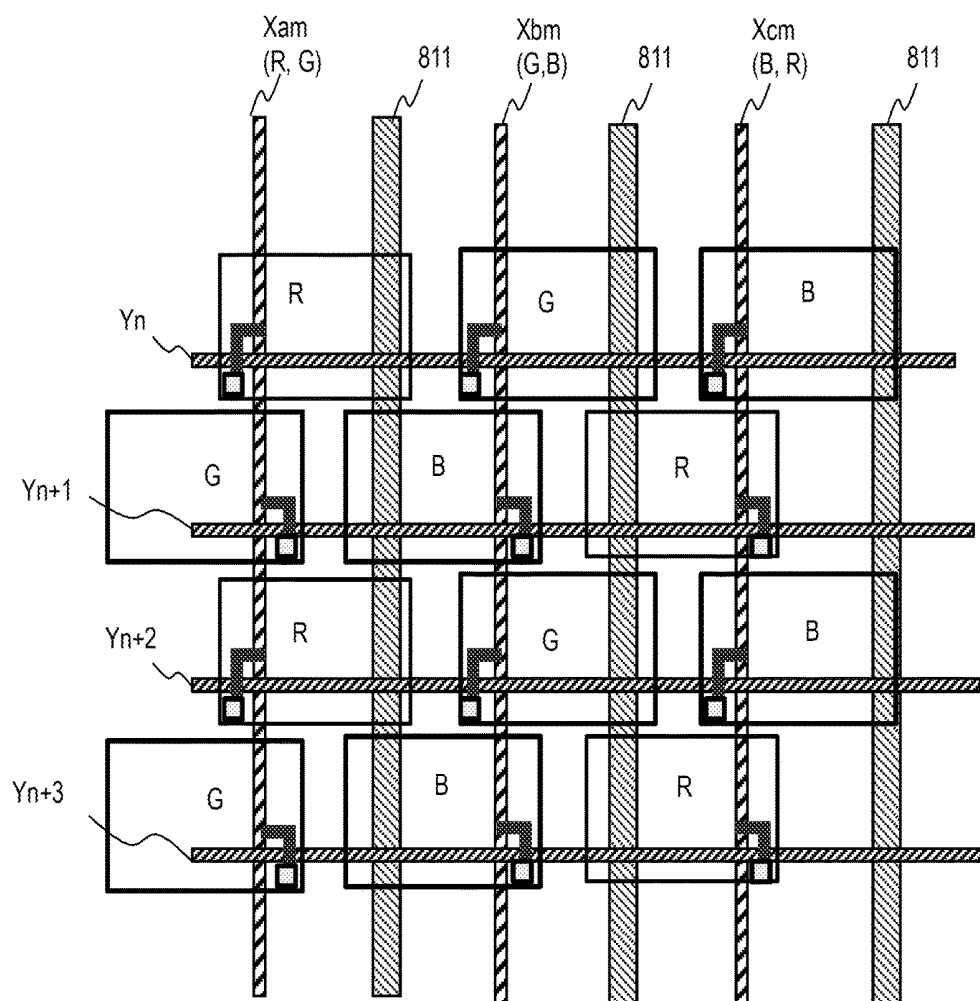


FIG. 9

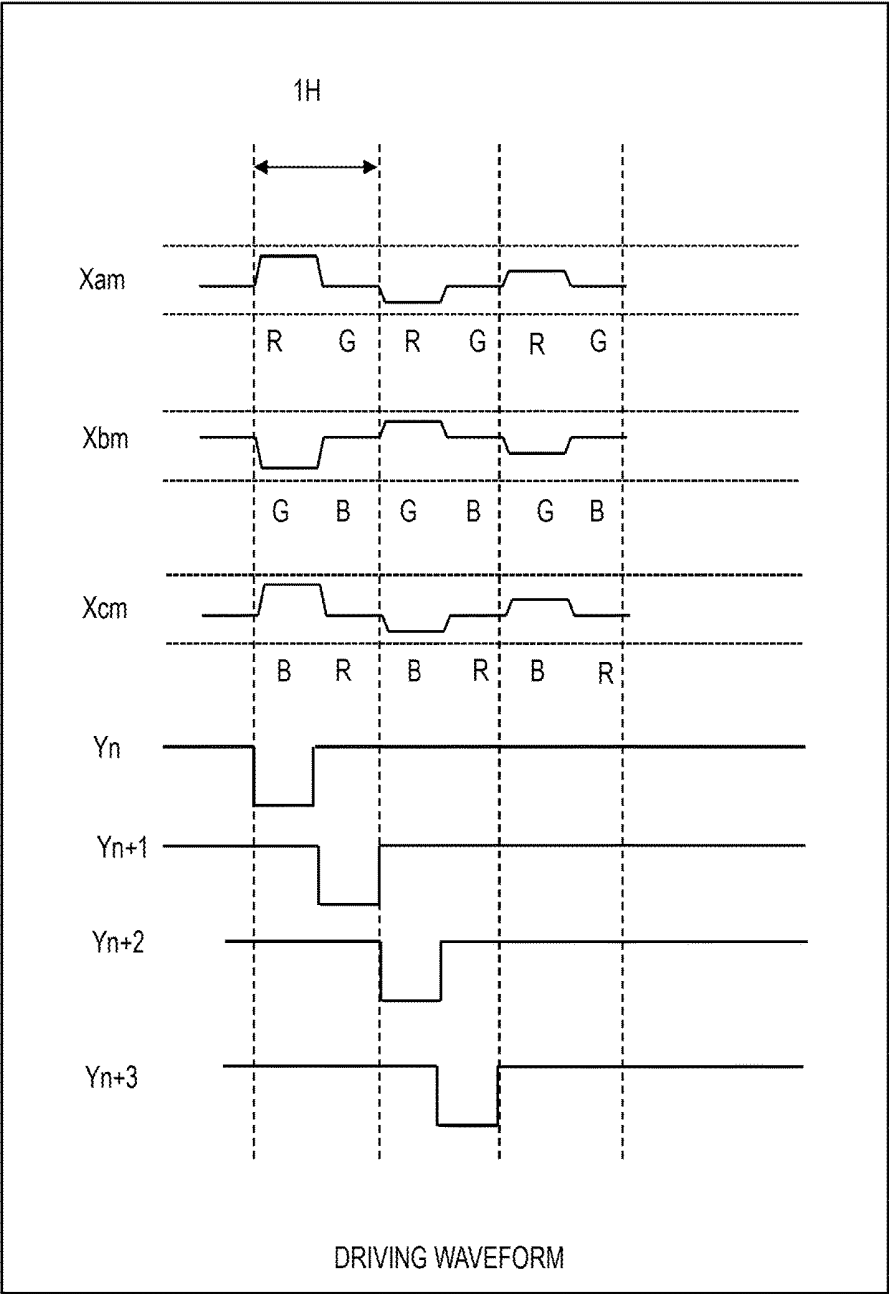


FIG. 10

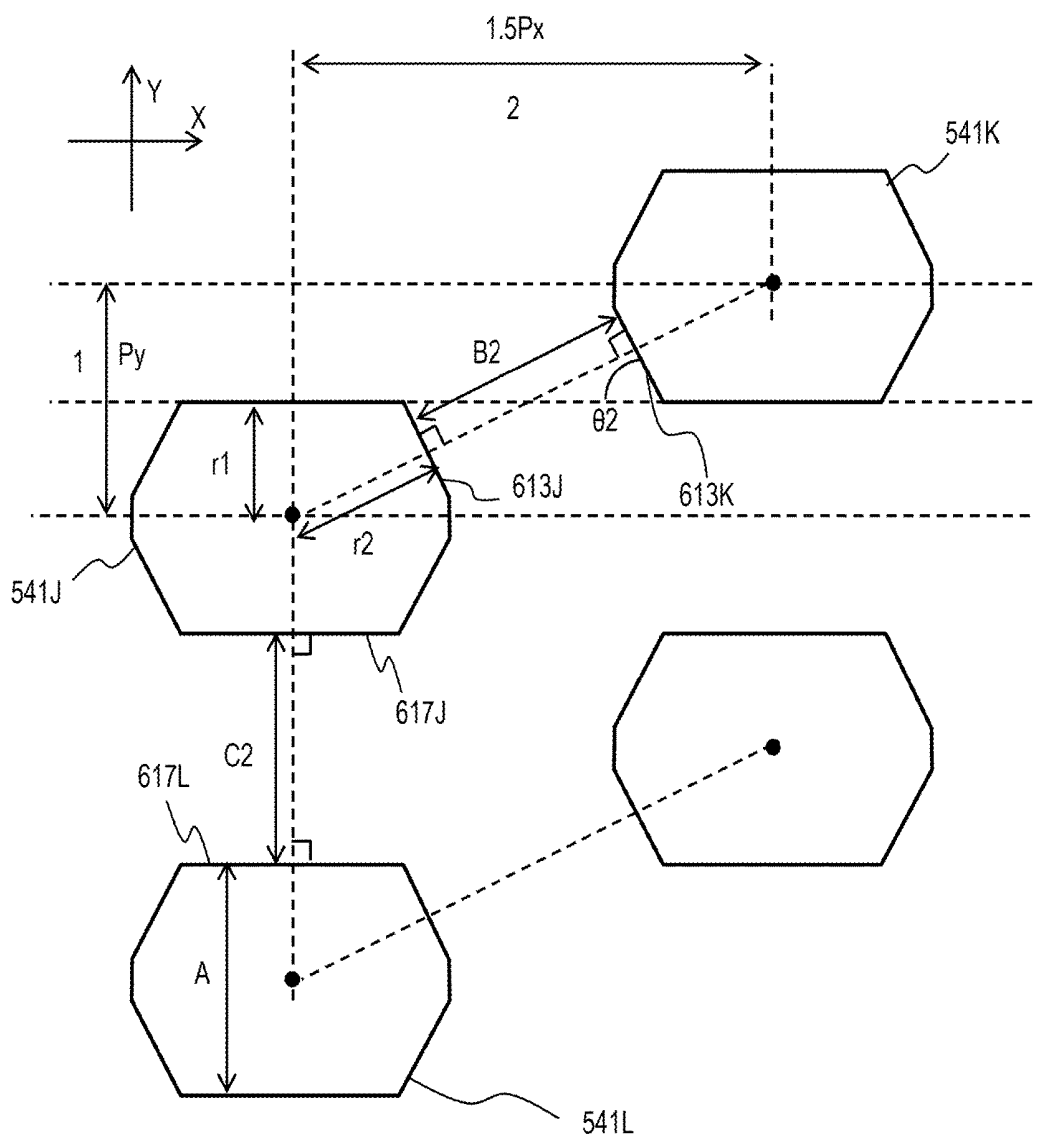


FIG. 11

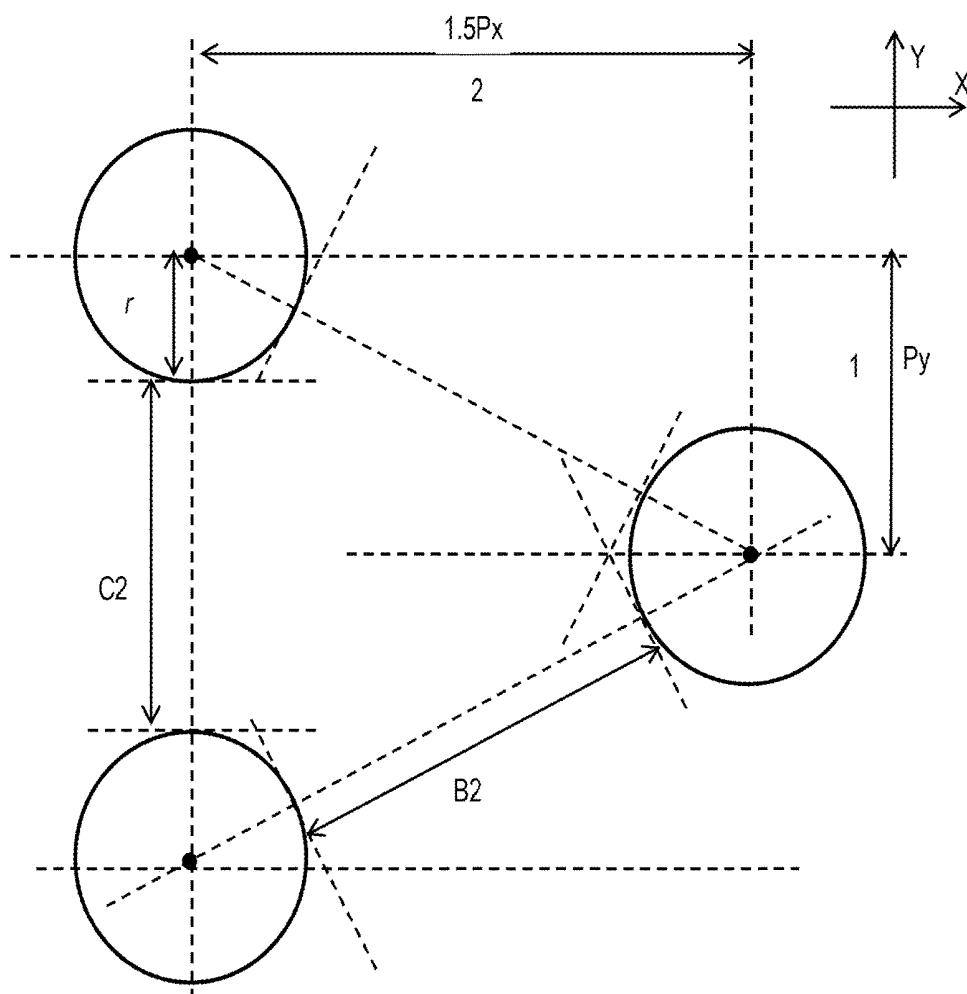


FIG. 12

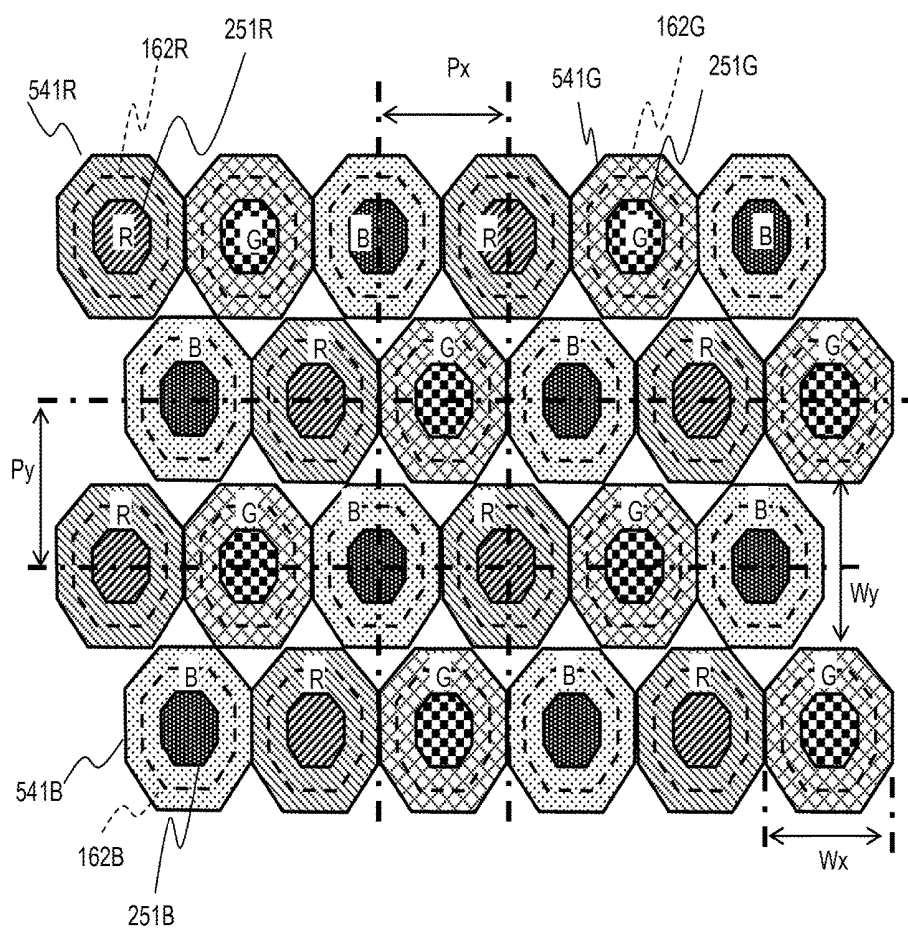


FIG. 13

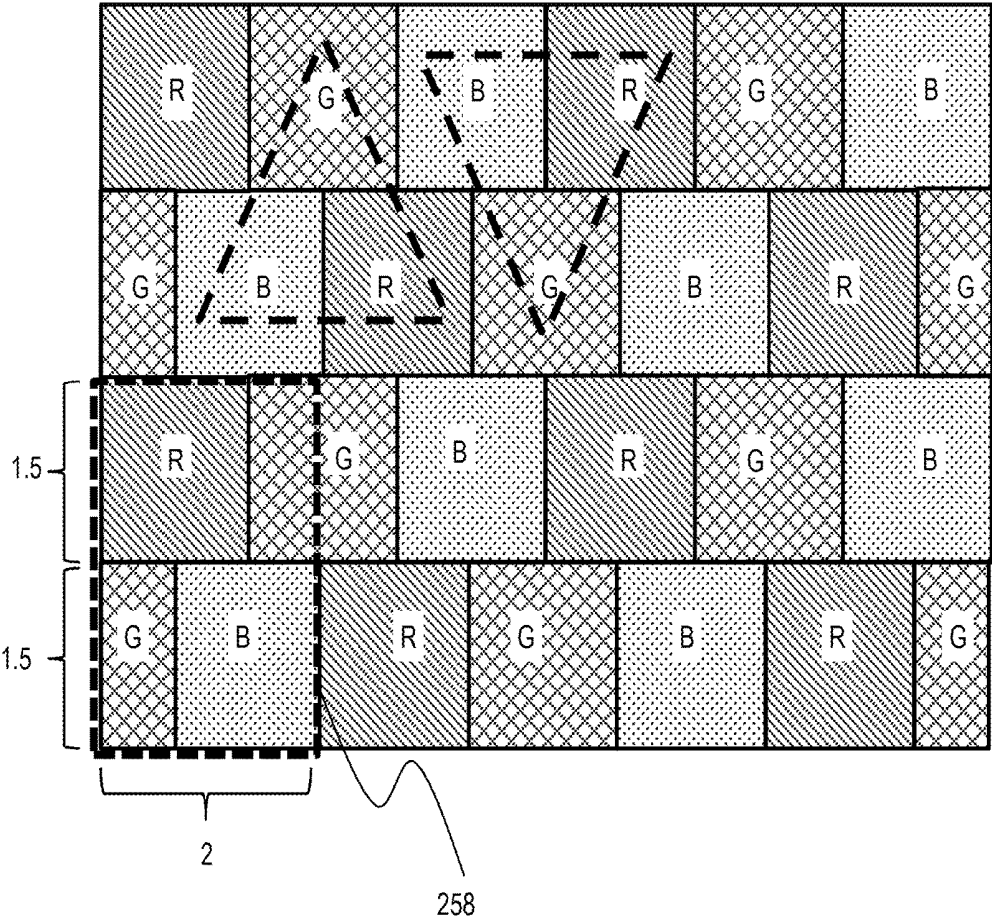


FIG. 14

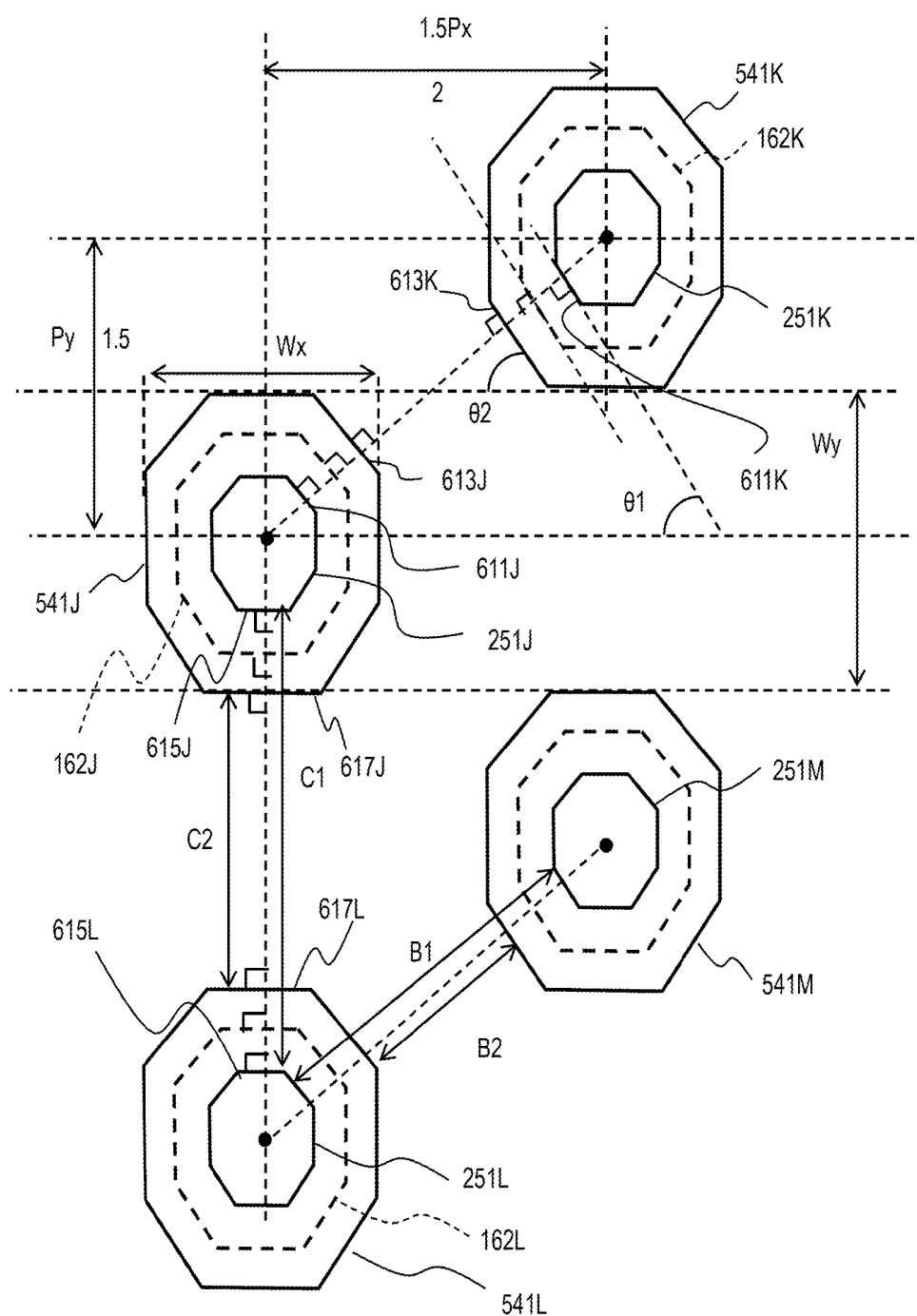


FIG. 15

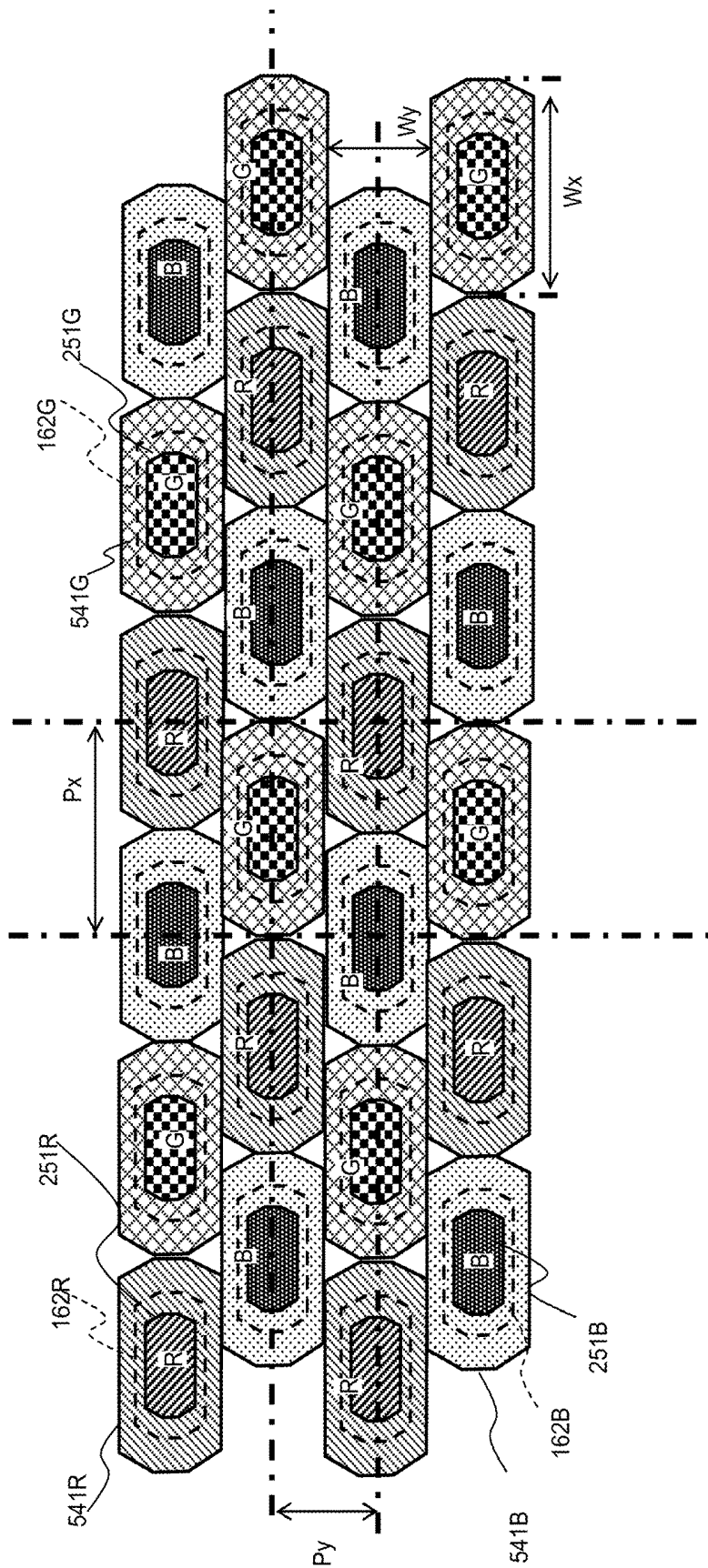


FIG. 16

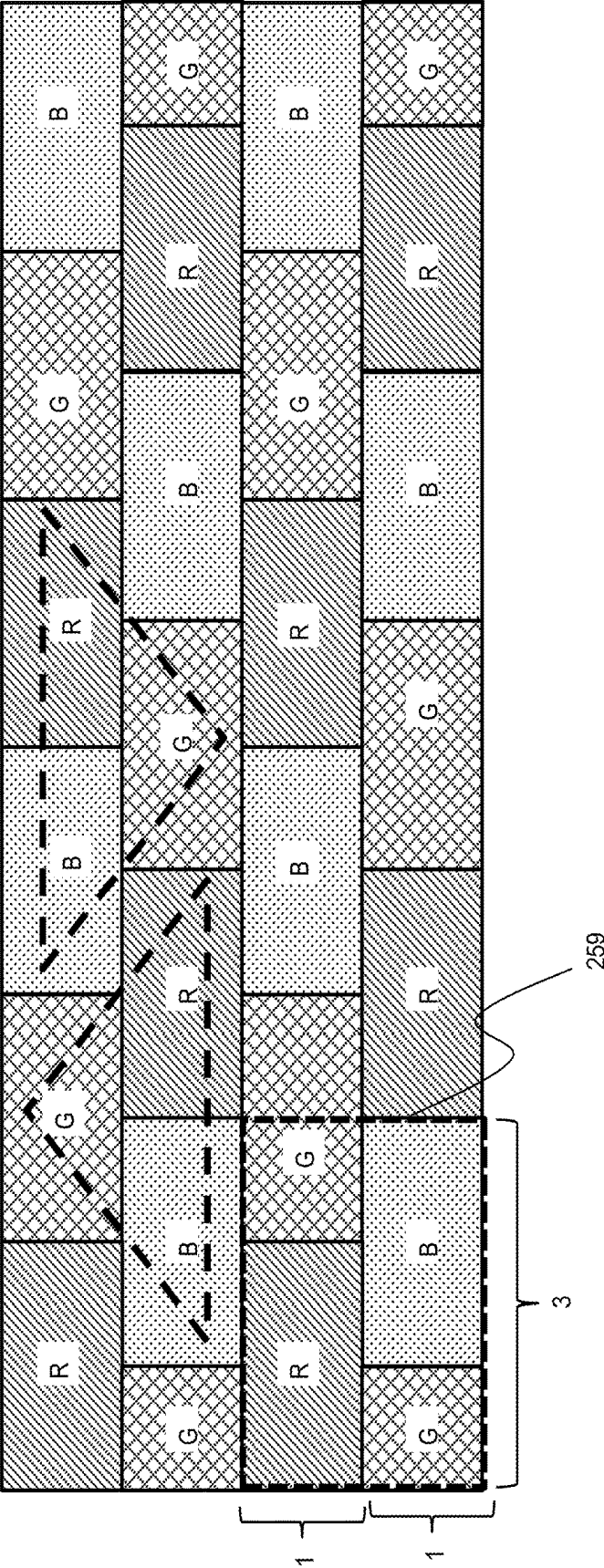


FIG. 17

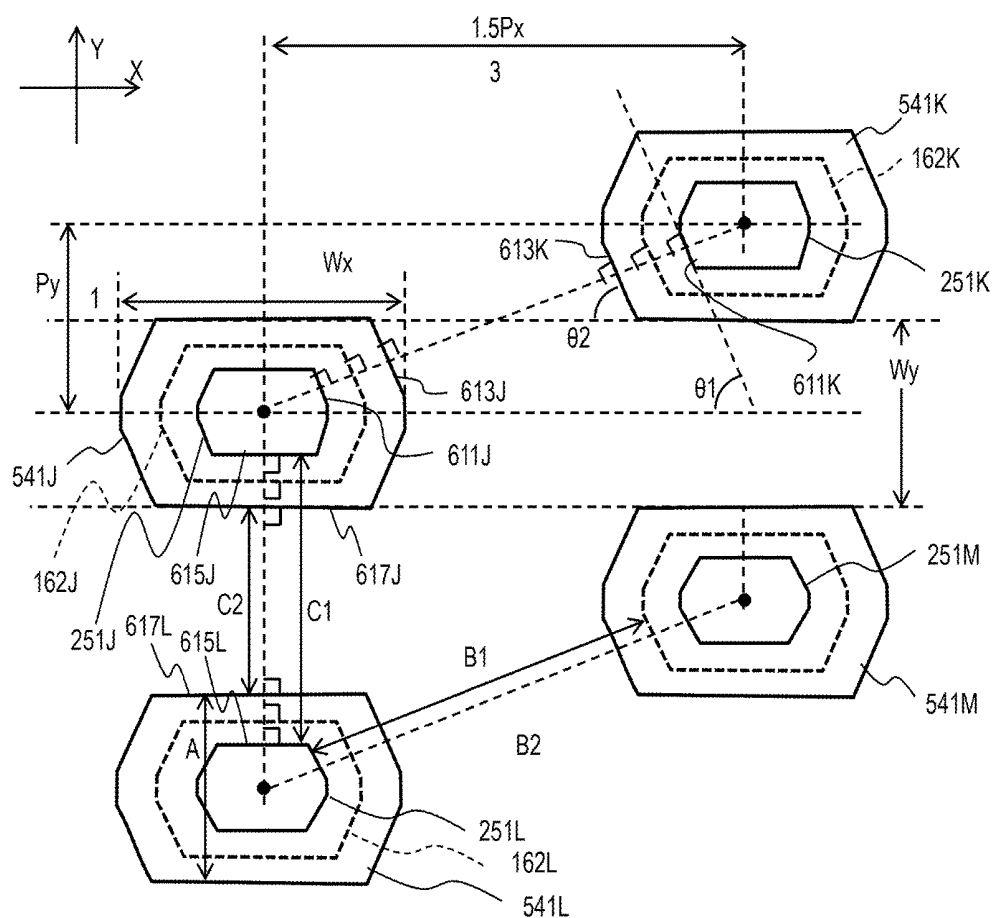


FIG. 18

OLED DISPLAY DEVICE, MASK, AND METHOD OF MANUFACTURING OLED DISPLAY DEVICE

CROSS-REFERENCE TO RELATED APPLICATIONS

[0001] This Non-provisional application claims priority under 35 U.S.C. § 119(a) on Patent Application No. 2017-207847 filed in Japan on Oct. 27, 2017, the entire content of which is hereby incorporated by reference.

BACKGROUND

[0002] This disclosure relates to an OLED display device, a mask, and a method of manufacturing an OLED display device.

[0003] In place of liquid crystal display devices, organic light-emitting diode (OLED) display devices have been proposed. The OLED element is a current-driven self-light-emitting element and therefore, eliminates the necessity of backlight. In addition to this, the OLED display element has advantages to achieve low power consumption, wide viewing angle, and high contrast ratio; it is expected to contribute to development of flat panel display devices.

[0004] An active matrix type of color OLED display device has a display region composed of red (R) pixels, green (G) pixels, and blue (B) pixels arrayed on a substrate. In view of the characteristics of the OLED display device and the manufacturing method thereof, various pixel layouts have been proposed as disclosed in US 2014/0197385 A and US 2015/0091785 A, for example.

[0005] There are two major ways of manufacturing the pixels for an OLED display device; one is color filtering method that produces three colors of R, G, and B from white OLED elements with color filters and the other is selective deposition method that applies organic light-emitting materials for the three R, G, and B colors separately. The color filtering method has a disadvantage of high power consumption because the color filters absorb light to lower the light usage rate. In contrast, the selective deposition method has advantages of high color purity to easily produce a wide color gamut and no color filters to achieve high light usage rate; accordingly, the selective deposition method is widely employed.

[0006] The selective deposition method uses sheet-like metal masks (called fine metal masks (FMM)) to selectively apply organic light-emitting materials for individual colors. An organic light-emitting material is applied (vapor-deposited) through openings provided in a metal mask to become a film. The metal mask deforms easily because of its structure.

[0007] Meanwhile, the trend toward higher definition in video or image format represented by the full HD format requires OLED display devices to have higher resolution. To manufacture an OLED display device having higher resolution and larger screen, the metal masks need to be thinner and larger, so that they deform more easily, causing a problem that selectively applying organic light-emitting materials with high precision is difficult.

SUMMARY

[0008] An aspect of the present disclosure is an OLED display device including: a plurality of pixels of a first color; a plurality of pixels of a second color; and a plurality of

pixels of a third color. The plurality of pixels of the first color, the plurality of pixels of the second color, and the plurality of pixels of the third color are provided in a plurality of pixel rows. Each of the plurality of pixel rows includes pixels disposed cyclically in order of the first color, the second color, and the third color at regular distances. The plurality of pixels of the first color, the plurality of pixels of the second color, and the plurality of pixels of the third color have the same polygonal shape that is symmetric about a line passing through the centroid thereof. The centroids of the pixels in each of the plurality of pixel rows are located on a line extending in a first direction. Distances between lines passing through the centroids of the pixels in each of the plurality of pixel rows are uniform. In each pair consisting of two pixel rows adjacent to each other in the plurality of pixel rows, each of the pixels of the first color in a first pixel row of the pair of the two pixel rows is located at the center in the first direction between pixels of the first color adjacent to each other in a second pixel row of the pair of the two pixel rows. The shortest distance between a perimeter of a first pixel of each of the first color, the second color, and the third color and a perimeter of a second pixel of the same color as the first pixel that is closest to the first pixel in a pixel row adjacent to the pixel row including the first pixel is a distance between a first point and a second point, the first point being where a centroid connecting line connecting the centroid of the first pixel and the centroid of the second pixel intersects with a side of the first pixel opposed to a side of the second pixel, the second point where the centroid connecting line intersects with the side of the second pixel opposed to the side of the first pixel. The side of the first pixel and the side of the second pixel opposed to each other are perpendicular to the centroid connecting line.

[0009] It is to be understood that both the foregoing general description and the following detailed description are exemplary and explanatory and are not restrictive of this disclosure.

BRIEF DESCRIPTION OF THE DRAWINGS

[0010] FIG. 1 schematically illustrates a configuration example of an OLED display device;

[0011] FIG. 2 schematically illustrates a part of a cross-sectional structure of an OLED display device;

[0012] FIG. 3A schematically illustrates a configuration example of a fine metal mask (FMM) module and a linear source to be used in vapor deposition of an organic light-emitting layer;

[0013] FIG. 3B schematically illustrates a configuration example of an FMM;

[0014] FIG. 4 illustrates an example of a pixel layout;

[0015] FIG. 5 illustrates a color pattern of the pixels in delta-nabla arrangement for real resolution;

[0016] FIG. 6 illustrates a relation among the row direction display pixel pitch DPx, the column direction display pixel pitch DPy, the row direction pixel pitch Px, and the column direction pixel pitch Py in the pixel layout of the octagonal pixels illustrated in FIG. 4;

[0017] FIG. 7 illustrates a layout of pixels of one of the colors of red, green, and blue, anode electrodes thereof, and FMM openings therefor;

[0018] FIG. 8 provides examples of the shape of a pixel or an FMM opening;

[0019] FIG. 9 schematically illustrates an example of a layout of pixels (anode electrodes thereof) and lines and an

example of connection of the pixels (anode electrodes thereof) and the lines in the same pixel layout as the one in FIG. 4;

[0020] FIG. 10 is a timing chart for driving the pixels in the pixel layout in FIG. 9;

[0021] FIG. 11 illustrates an FMM opening layout of an FMM for one of the colors of red, green, and blue;

[0022] FIG. 12 illustrates another example of an FMM opening layout of an FMM for one of the colors of red, green, and blue;

[0023] FIG. 13 illustrates a pixel layout of delta-nabla arrangement for displaying an image by rendering;

[0024] FIG. 14 illustrates a color pattern of the pixels for delta-nabla vertical direction $\frac{2}{3}$ pixel rendering;

[0025] FIG. 15 illustrates a layout of pixels of one of the colors of red, green, and blue, anode electrodes thereof, and FMM openings therefor for the delta-nabla vertical direction $\frac{2}{3}$ pixel rendering;

[0026] FIG. 16 illustrates another pixel layout of delta-nabla arrangement for displaying an image by rendering;

[0027] FIG. 17 illustrates a color pattern of the pixels for delta-nabla horizontal direction $\frac{2}{3}$ pixel rendering; and

[0028] FIG. 18 illustrates a layout of pixels of one of the colors of red, green, and blue, anode electrodes thereof, and FMM openings therefor for the delta-nabla horizontal direction $\frac{2}{3}$ pixel rendering.

EMBODIMENTS

[0029] Hereinafter, embodiments of this disclosure will be described with reference to the accompanying drawings. It should be noted that the embodiments are merely examples to implement this disclosure and are not to limit the technical scope of this disclosure. Elements common to the drawings are denoted by the same reference signs.

Configuration of Display Device

[0030] An overall configuration of a display device 10 in this disclosure is described with reference to FIGS. 1 and 2. The elements in the drawings may be exaggerated in size or shape for clear understanding of the description.

[0031] FIG. 1 schematically illustrates a configuration example of an organic light-emitting diode (OLED) display device 10 in this disclosure. The OLED display device 10 includes a thin film transistor (TFT) substrate 100 on which OLED elements are formed, an encapsulation substrate 200 for encapsulating the OLED elements, and a bond (glass frit sealer) 300 for bonding the TFT substrate 100 with the encapsulation substrate 200. The space between the TFT substrate 100 and the encapsulation substrate 200 is filled with dry air and sealed up with the bond 300.

[0032] In the periphery of a cathode electrode forming region 114 outer than the display region 125 of the TFT substrate 100, a scanning driver 131, an emission driver 132, a protection circuit 133, and a driver IC 134 are provided. These are connected to the external devices via flexible printed circuits (FPC) 135.

[0033] The scanning driver 131 drives scanning lines on the TFT substrate 100. The emission driver 132 drives emission control lines to control the light emission periods of pixels. The protection circuit 133 protects the elements from electrostatic discharge. The driver IC 134 is mounted with an anisotropic conductive film (ACF), for example.

[0034] The driver IC 134 provides power and timing signals (control signals) to the scanning driver 131 and the emission driver 132 and further, provides data voltage corresponding to image data to the data lines. In other words, the driver IC has a display control function.

[0035] Next, a detailed structure of the OLED display device 10 is described. FIG. 2 schematically illustrates a part of a cross-sectional structure of the OLED display device 10. The OLED display device 10 includes a TFT substrate 100 and an encapsulation substrate (transparent substrate) 200 opposed to the TFT substrate 100. The definitions of top and bottom in the following description correspond to the top and the bottom of the drawing.

[0036] As illustrated in FIG. 2, the OLED display device 10 includes an insulating substrate 151 and an encapsulation structural unit opposed to the insulating substrate 151. An example of the encapsulation structural unit is a flexible or inflexible encapsulation substrate 200. The encapsulation structural unit can be a thin film encapsulation (TFE) structure, for example.

[0037] The OLED display device 10 includes a plurality of lower electrodes (for example, anode electrodes 162), one upper electrode (for example, a cathode electrode 166), and a plurality of organic light-emitting layers 165 disposed between the insulating substrate 151 and the encapsulation structural unit. The cathode electrode 166 is a transparent electrode that transmits the light from the organic light-emitting layers 165 (also referred to as organic light-emitting films 165) toward the encapsulation structural unit.

[0038] An organic light-emitting layer 165 is disposed between the cathode electrode 166 and an anode electrode 162. The plurality of anode electrodes 162 are disposed on the same plane (for example, on a planarization film 161) and an organic light-emitting layer 165 is disposed on an anode electrode 162.

[0039] The OLED display device 10 further includes a plurality of spacers 164 standing toward the encapsulation structural unit and a plurality of circuits each including a plurality of switches. Each of the plurality of circuits is formed between the insulating substrate 151 and an anode electrode 162 and controls the electric current to be supplied to the anode electrode 162.

[0040] FIG. 2 illustrates an example of a top-emission pixel structure. The top-emission pixel structure is configured in such a manner that the cathode electrode 166 common to a plurality of pixels is provided on the light emission side (the upper side of the drawing). The cathode electrode 166 has a shape that fully covers the entire display region 125. The features of this disclosure are also applicable to an OLED display device having a bottom-emission pixel structure. The bottom-emission pixel structure has a transparent anode electrode and a reflective cathode electrode to emit light to the external through the TFT substrate 100.

[0041] Hereinafter, the OLED display device 10 is described in more detail. The TFT substrate 100 includes pixels (also called sub-pixels) arrayed within the display region and lines provided in the wiring region surrounding the display region. The lines connect the pixel circuits with the control circuits (131, 132, 134) provided in the wiring region.

[0042] A pixel is a light emitting region for displaying one of the colors of red, green, and blue. The light emitting region is included in an OLED element, which is composed

of an anode electrode of a lower electrode, an organic light-emitting layer, and a cathode electrode of an upper electrode. A plurality of OLED elements are formed of one cathode electrode **166**, a plurality of anode electrodes **162**, and a plurality of organic light-emitting layers **165**.

[0043] The insulating substrate **151** is made of glass or resin, for example, and is flexible or inflexible. In the following description, the side closer to the insulating substrate **151** is defined as lower side and the side farther from the insulating substrate **151** is defined as upper side. An insulating film **152** is formed on the insulating substrate **151**. Channels **155** are formed on the insulating substrate **151**. Gate electrodes **157** are provided above the channels **155** with a gate insulating film **156** interposed. An interlayer insulating film **158** is provided over the gate electrodes **157**.

[0044] Within the display region **125**, source electrodes **159** and drain electrodes **160** are provided above the interlayer insulating film **158**. The source electrodes **159** and the drain electrodes **160** are formed of a metal having a high melting point or an alloy of such a metal. Each source electrode **159** and each drain electrode **160** are connected with the channel **155** through contacts **168** and **169** provided in contact holes of the interlayer insulating film **158**.

[0045] Over the source electrodes **159** and the drain electrodes **160**, an insulative planarization film **161** is provided. Above the insulative planarization film **161**, anode electrodes **162** are provided. Each anode electrode **162** is connected with a drain electrode **160** through a contact provided in a contact hole in the planarization film **161**. The pixel circuits (TFTs) are formed below the anode electrodes **162**.

[0046] Above the anode electrodes **162**, an insulative pixel defining layer (PDL) **163** is provided to separate OLED elements. An OLED element is composed of an anode electrode **162**, an organic light-emitting layer **165**, and the cathode electrode **166** (a part thereof) laminated together. The light emitting region of an OLED element is formed in an opening **167** of the pixel defining layer **163**.

[0047] Each insulative spacer **164** is provided on the pixel defining layer **163** and between anode electrodes **162**. The top face of the spacer **164** is located higher than the top face of the pixel defining layer **163** or closer to the encapsulation substrate **200** and maintains the space between the OLED elements and the encapsulation substrate **200** by supporting the encapsulation substrate **200** when the encapsulation substrate **200** is deformed.

[0048] Above each anode electrode **162**, an organic light-emitting layer **165** is provided. The organic light-emitting layer **165** is in contact with the pixel defining layer **163** in the opening **167** of the pixel defining layer **163** and its periphery. A cathode electrode **166** is provided over the organic light-emitting layer **165**. The cathode electrode **166** is a transparent electrode. The cathode electrode **166** transmits all or part of the visible light from the organic light-emitting layer **165**.

[0049] The laminated film of the anode electrode **162**, the organic light-emitting layer **165**, and the cathode electrode **166** formed in an opening **167** of the pixel defining layer **163** corresponds to an OLED element. Electric current flows only within the opening **167** of the pixel defining layer **163** and accordingly, the region of the organic light-emitting layer **165** exposed in the opening **167** is the light emitting region of the OLED element (pixel). The cathode electrode **166** is common to the anode electrodes **162** and the organic

light-emitting layers **165** (OLED elements) that are formed separately. A not-shown cap layer may be provided over the cathode electrode **166**.

[0050] The encapsulation substrate **200** is a transparent insulating substrate, which can be made of glass. A $\lambda/4$ plate **201** and a polarizing plate **202** are provided over the light emission surface (top face) of the encapsulation substrate **200** to prevent reflection of light entering from the external.

Manufacturing Method

[0051] An example of a method of manufacturing the OLED display device **10** is described. In the following description, the elements formed in the same process (simultaneously) are the elements on the same layer. The method of manufacturing the OLED display device **10** first deposits silicon nitride, for example, onto the insulating substrate **151** by chemical vapor deposition (CVD) to form a first insulating film **152**.

[0052] Next, the method forms a layer (poly-silicon layer) including channels **155** by a known low-temperature poly-silicon TFT fabrication technique. For example, the method can form the poly-silicon layer by depositing amorphous silicon by CVD and crystalizing the amorphous silicon by excimer laser annealing (ELA). The poly-silicon layer is used to connect elements within the display region **125**.

[0053] Next, the method deposits silicon oxide, for example, onto the poly-silicon layer including the channels **155** by CVD to form a gate insulating film **156**. Furthermore, the method deposits a metal by sputtering and patterns the metal to form a metal layer including gate electrodes **157**.

[0054] The metal layer includes storage capacitor electrodes, scanning lines, emission control lines, and power lines, in addition to the gate electrodes **157**. The metal layer may be a single layer made of one material selected from a group consisting of Mo, W, Nb, MoW, MoNb, Al, Nd, Ti, Cu, a Cu alloy, an Al alloy, Ag, and an Ag alloy. Alternatively, the metal layer may be a laminated layer to reduce the wiring resistance. The laminated layer has a multi-layer structure including two or more layers each made of a low-resistive material such as Mo, Cu, Al, Ag or an alloy thereof.

[0055] Next, the method dopes additional impurities to the channels **155** doped with high-concentration impurities before formation of the gate electrodes **157**, using the gate electrodes **157** as a mask. As a result, a layer of low-concentration impurities is formed and the TFTs are provided with lightly doped drain (LDD) structure. Next, the method deposits silicon oxide by CVD to form an interlayer insulating film **158**.

[0056] The method opens contact holes in the interlayer insulating film **158** and the gate insulating film **156** by anisotropic etching. The contact holes for the contacts **168** and **169** to connect the source electrodes **159** and the drain electrodes **160** to the channels **155** are formed in the interlayer insulating film **158** and the gate insulating film **156**.

[0057] Next, the method deposits an aluminum alloy such as Ti/Al/Ti by sputtering and patterns the alloy to form a metal layer. The metal layer includes source electrodes **159**, drain electrodes **160**, and contacts **168** and **169**. In addition to these, data lines and power lines are also formed.

[0058] Next, the method deposits a photosensitive organic material to form a planarization film **161**. Subsequently, the method opens contact holes for connecting to the source

electrodes **159** and the drain electrodes **160** of the TFTs. The method forms anode electrodes **162** on the planarization film **161** having contact holes. An anode electrode **162** includes three layers of a transparent film made of ITO, IZO, ZnO, In₂O₃, or the like, a reflective film made of Ag, Mg, Al, Pt, Pd, Au, Ni, Nd, Ir, Cr, or a metallic compound thereof, and another transparent film as mentioned above. The three-layer structure of the anode electrode **162** is an example and the anode electrode **162** may have a two-layer structure. The anode electrodes **162** are connected to the drain electrodes **160** through contacts.

[0059] Next, the method deposits a photosensitive organic resin by spin coating and patterns the photosensitive organic resin to form a pixel defining layer **163**. The patterning creates holes in the pixel defining layer **163** to expose the anode electrodes **162** of the pixels at the bottom of the created holes. The pixel defining layer **163** forms separate light emitting regions of pixels. The method further deposits a photosensitive organic resin by spin coating and patterns the photosensitive organic resin to form spacers **164** on the pixel defining layer **163**.

[0060] Next, the method applies organic light-emitting materials onto the insulating substrate **151** with the pixel defining layer **163** provided to form organic light-emitting layers **165**. The organic light-emitting layers **165** are formed by depositing organic light-emitting materials for the individual colors of R, G, and B selectively onto the anode electrodes **162**. Forming the organic light-emitting layers **165** uses fine metal masks (FMMs). The FMM can be simply called a metal mask.

[0061] An FMM is prepared for a pattern of the pixels of a specific color and a plurality of FMMs are prepared for different colors. The method places and attaches an FMM onto the surface of the TFT substrate **100** in correct alignment. The method evaporates an organic light-emitting material to be deposited onto the places corresponding to the pixels on the TFT substrate **100** through the openings of the FMM. The FMM and the vapor deposition using the FMM will be described later in detail.

[0062] Next, the method applies a metal material for the cathode electrode **166** onto the TFT substrate **100** where the pixel defining layer **163**, the spacers **164**, and the organic light-emitting layers **165** (in the openings of the pixel defining layer **163**) are exposed. The metal material adheres to the pixel defining layer **163**, the spacers **164** and the organic light-emitting layers **165**. The metal material deposited on the organic light-emitting layer **165** of one pixel functions as the cathode electrode **166** of the pixel.

[0063] The layer of the transparent cathode electrode **166** is formed by vapor deposition of Li, Ca, LiF/Ca, LiF/Al, Al, Mg, or an alloy thereof, for example. The film thickness of the cathode electrode **166** is optimized to achieve high light-extraction efficiency and good viewing angle dependence. If the resistance of the cathode electrode **166** is so high to impair the uniformity of the luminance of the emitted light, an auxiliary electrode layer may be added using a material for a transparent electrode, such as ITO, IZO, ZnO, or In₂O₃. To increase the light extraction efficiency, a cap layer may be formed by depositing an insulator having a higher refractive index than glass, after forming the cathode electrode **166**.

[0064] Through the foregoing processes, OLED elements corresponding to R, G, and B pixels are formed; the regions where the anode electrodes **162** are in contact with the

organic light-emitting layers **165** (in the openings in the pixel defining layer **163**) become R light emitting regions (R pixels), G light emitting regions (G pixels), and B light emitting regions (B pixels).

[0065] Next, the method applies glass frit to the periphery of the TFT substrate **100**, places an encapsulation substrate **200** thereon, and heats and melts the glass frit with a laser beam to seal the TFT substrate **100** and the encapsulation substrate **200**. Thereafter, the method forms a $\lambda/4$ plate **201** and a polarizing plate **202** on the light emission side of the encapsulation substrate **200** to complete the fabrication of the OLED display device **10**.

[0066] Hereinafter, details of the vapor deposition of an organic light-emitting layer are described. The manufacturing system for the OLED display device **10** selectively deposits organic light-emitting materials with FMMs. The manufacturing system sets FMMs having openings a little larger than light emitting regions one after another on the TFT substrate **100** in correct alignment to selectively deposit the organic light-emitting materials for individual colors. Since the electric current flows only within the openings of the pixel defining layer **163**, these regions become light emitting regions (pixels).

[0067] FIG. 3A schematically illustrates a configuration example of an FMM module **500** and a linear source **400** to be used in vapor deposition of an organic light-emitting layer. The FMM module **500** is used to deposit an organic light-emitting material onto a motherboard including the panels for a plurality of OLED display devices. The panel for each OLED display device is cut out from the motherboard.

[0068] The FMM module **500** includes a frame **501** and a plurality of strip-like FMMs **503**. For example, the frame **501** has a rectangular shape and consists of parts corresponding to four sides to surround a central opening. The frame **501** is structured to have sufficient stiffness and small thermal deformability to hold stretched FMM **503** with high precision. To achieve small thermal deformation, the frame **501** is formed of Invar, for example. The shape and the material of the frame **501** depends on the design.

[0069] In FIG. 3A, each of the plurality of FMMs **503** is secured to the frame **501** in the state where the FMM **503** is stretched longitudinally (along the X-axis). Each FMM **503** is secured to the frame **501** at the fixing points **505** on the four corners. In securing the FMM **503** to the frame **501**, the FMM **503** is being pulled in the longitudinal direction (along the X-axis). The tension reduces the deformation of the FMM **503**. The FMM **503** can be made of nickel, a nickel alloy, or a nickel-cobalt alloy, for example. The material of the FMM **503** depends on the design.

[0070] A plurality of FMMs **503**, four FMMs **503** in FIG. 3A, are disposed along the axis (the Y-axis) perpendicular to the direction of pull (the X-axis direction). The number of the FMMs **503** can be any, but not less than one.

[0071] Each FMM **503** has a plurality of mask patterns **532**. In the example of FIG. 3A, each FMM **503** has three mask patterns **532** disposed along the longitudinal axis (the X-axis). One mask pattern **532** corresponds to the pattern of pixels for one color in the active area of one OLED display device **10**. The number of mask patterns **532** in one FMM **503** can be any, but not less than one.

[0072] The linear source **400** has multiple nozzles **401** disposed linearly along the longitudinal axis (the X-axis). The linear source **400** moves back and forth along the axis

(the Y-axis) perpendicular to the disposition of the nozzles **401** over the FMM module **500** to vapor-deposit the organic light-emitting material from the nozzles **401** onto the motherboard.

[0073] The direction of movement of the linear source **400** (the Y-axis direction) is perpendicular to the direction of pulling the FMM **503** (the X-axis direction). In the alignment of the FMM **503**, the error is large in the direction of pull (the X-axis direction) and small in the direction perpendicular thereto (the Y-axis direction). Accordingly, the linear source **400** moves perpendicularly to the direction of pull (moves along the Y-axis). All mask patterns **532** of each FMM **503** are provided between the nozzles **401** at both ends in the X-axis direction. The linear source **400** moves along the Y-axis to deposit the organic light-emitting material onto the motherboard through all mask patterns **532**.

[0074] FIG. 3B schematically illustrates a configuration example of an FMM **503**. The orientations of the X-axis and the Y-axis in FIG. 3B are the same as those in FIG. 3A. The FMM **503** has a substantially rectangular shape. The FMM **503** is pulled in the longitudinal direction (along the X-axis) and secured to the frame **501**. The FMM **503** includes a substrate body **531** and multiple mask patterns **532** disposed along the longitudinal axis (the X-axis). In the example of FIG. 3B, three mask patterns **532** are provided.

[0075] Each mask pattern **532** is an opening pattern for the active area of one OLED display device **10**. The mask pattern **532** corresponds to the pattern of the R, G, or B pixels in the active area. The mask pattern **532** is composed of openings provided correspondingly to the pixel array and a masking part surrounding the openings. Each opening corresponds to a pixel; the organic light-emitting material that passes through the opening adheres to the anode electrode **162** of the corresponding pixel.

[0076] The FMM **503** further includes a plurality of dummy patterns **533** and a plurality of half-etched regions **534**. In FIG. 3B, only two of the six dummy patterns are provided with a reference sign **533** by way of example. Each pair of the three pairs of dummy patterns **533** are provided to sandwich a mask pattern **532** in the Y-axis direction.

[0077] In FIG. 3B, only two of four half-etched regions are provided with a reference sign **534** by way of example. The half-etched regions **534** are formed to sandwich the mask patterns **532** in the X-axis direction. Two half-etched regions **534** are formed on one side and the other two half-etched regions **534** are formed on the other side. The dummy patterns **533** and the half-etched regions **534** are formed so that the FMM **503** is stretched uniformly in response to pulling. Whether to provide the dummy patterns **533** and the half-etched regions **534**, and the numbers, the locations, and the shapes of the dummy patterns **533** and the half-etched regions **534** are selectable depending on the design.

[0078] The region **537** is an enlarged view of a part of a mask pattern **532**. FMM openings **541** are formed regularly to correspond to the pixel array. The anode electrodes **162** of the pixels are exposed at the FMM openings **541**. The organic light-emitting material passes through the FMM openings **541** and adheres to the anode electrodes **162** within the openings **167** of the pixel defining layer **163**. The regions of the organic light-emitting material above the anode electrodes **162** are the light emitting regions, namely the pixels **251**.

Layout of Pixels and FMM Openings

[0079] FIG. 4 illustrates an example of the pixel layout of this disclosure. FIG. 4 illustrates a relation of the layout of pixels (light emitting regions), the layout of anode electrodes **162**, and the layout of openings of three FMMs to be used in vapor deposition of organic light-emitting layers **165**. As described above, different FMMs are prepared for individual colors of R, G, and B; patterns of the organic light-emitting layer for each color are formed on the substrate by vapor deposition through the openings of each FMM. FIG. 4 includes opening patterns of three FMMs. The concept of this disclosure is applicable to pixels of a color group different from the color group of R, G, and B.

[0080] FIG. 4 includes four pixel rows by way of example. Each pixel row is composed of pixels disposed in the X-axis direction (first direction) in FIG. 4. The direction in which the pixels constituting a pixel row are disposed is also referred to as row direction. A plurality of pixel rows are disposed in the column direction (second direction) which is perpendicular to the row direction. In FIG. 4, the Y-axis direction corresponds to the column direction.

[0081] Each pixel row is composed of a plurality of R pixels **251R**, a plurality of G pixels **251G**, and a plurality of B pixels **251B**. In FIG. 4, one R pixel **251R**, one G pixel **251G**, and one B pixel **251B** are provided with reference signs by way of example.

[0082] In each pixel row, pixels of three colors are cyclically disposed at regular distances (pitch) P_x . In the example of FIG. 4, the pixels constituting a pixel row are disposed cyclically in the order of an R pixel **251R**, a G pixel **251G**, and a B pixel **251B**. In the cyclic disposition, the colors of the pixels on both sides are common to the pixels of the same color and the distances between pixels of the same color adjacent to each other are the same $3P_x$. The distance between adjacent pixels of the same color is common to the pixels of each color. The order of color is common to all pixel rows.

[0083] In the example of FIG. 4, the R pixels **251R**, the G pixels **251G**, and the B pixels **251B** have the same shape. Specifically, each pixel has an octagonal shape symmetric about a given line passing through its centroid and two sides thereof are parallel to the row direction. The centroids of the pixels constituting a pixel row are located on a straight line extending in the row direction. The pixel pitch P_x in a pixel row corresponds to the distance between the centroids of pixels adjacent to each other.

[0084] A plurality of pixel rows are disposed at regular distances (pitch) P_y in the column direction. The pitch P_y is a distance between lines passing through the centroids of the pixels in two pixel rows adjacent to each other. The pixel layout is a staggered arrangement. The locations and the colors of the pixels in the pixel row are the same among the odd-numbered pixel rows. In similar, the locations and the colors of the pixels in the pixel row are the same among the even-numbered pixel rows.

[0085] Each pixel row is different in position with respect to its adjacent pixel rows by $(3/2)P_x$. In each pixel row, a pixel is located at the center between pixels of the same color adjacent to each other in each of the two adjacent pixel rows. Specifically, the centroid of a pixel is located at the center between the centroids of pixels of the same color adjacent to each other in each of the two adjacent pixel rows.

[0086] For example, one R pixel **251R** is located at the center between two R pixels **251R** adjacent to each other in

a pixel row adjacent to the pixel row including the R pixel **251R**. In similar, one G pixel **251G** or one B pixel **251B** is located at the center between two G pixels **251R** adjacent to each other or two B pixels **251B** adjacent to each other in a pixel row adjacent to the G pixel **251G** or the B pixel **251B**. [0087] FIG. 4 provides a pixel layout for real resolution. Each pixel of a displayed image (also referred to as display pixel or main pixel) is composed of an R pixel **251R**, a G pixel **251G** and a B pixel **251B** adjacent to one another. In FIG. 4, two display pixels **255A** and **255B** are provided with reference signs by way of example.

[0088] The display pixel **255A** has a delta (triangular) shape. Specifically, the display pixel **255A** consists of a G pixel **251G** in the k-th row (k is a natural number) and an R pixel **251R** and a B pixel **251B** in the (k+1)th row. The display pixel **255B** has a nabla (inverted-triangular) shape. Specifically, the display pixel **255B** consists of an R pixel **251R** and a B pixel **251B** in the k-th row (k is a natural number) and a G pixel **251G** in the (k+1)th row. FIG. 4 provides so-called delta-nabla arrangement of display pixels. The delta-nabla arrangement has a configuration in which display pixels **255A** having a delta shape and display pixels **255B** having a nabla shape are disposed alternately.

[0089] The anode electrodes **162** of the pixels are larger than the pixels (openings **167** of the pixel defining layer) and have similar shapes (outlines) to the pixels. Specifically, the anode electrode **162R** of an R pixel **251R** is larger than the R pixel **251R** and has an octagonal shape similar to the R pixel **251R**. In similar, the anode electrode **162G** of a G pixel **251G** and the anode electrode **162B** of a B pixel **251B** are larger than the G pixel **251G** and the B pixel **251B**, respectively, and have octagonal shapes similar to the G pixel **251G** and the B pixel **251B**, respectively. The ratio of a pixel to the anode electrode thereof is common to all pixels.

[0090] The centroids of the pixel and its anode electrode are located at the same points when seen in the stacking direction. In other words, the centroids of an R pixel **251R**, a G pixel **251G**, and a B pixel **251B** are located at the same points as the centroids of their anode electrodes **162R**, **162G**, and **162B**, respectively, when seen in the stacking direction. As understood from the foregoing description about the relation between pixels and their anode electrodes, the description about the pixels and pixel rows is applicable to the anode electrodes and the rows of anode electrodes.

[0091] The openings of an FMM to deposit an organic light-emitting material of pixels are larger than the pixels (openings **167** of the pixel defining layer) and the anode electrodes and have similar shapes (similar outlines) to the pixels. Specifically, the FMM opening **541R** for an R pixel **251R** is larger than the R pixel **251R** and its anode electrode **162R** and has an octagonal shape similar to the R pixel **251R**.

[0092] In similar, the FMM opening **541G** for a G pixel **251G** is larger than the G pixel **251G** and its anode electrode **162G** and has an octagonal shape similar to the G pixel **251G**. Furthermore, the FMM opening **541B** for a B pixel **251B** is larger than the B pixel **251B** and its anode electrode **162B** and has an octagonal shape similar to the B pixel **251B**. The ratio of a pixel to the FMM opening therefor is common to all pixels.

[0093] FIG. 4 provides a pixel layout and an FMM opening layout in which the centroids of the pixels are located at the same points as the centroids of the FMM openings for the pixels when seen in the stacking direction. FIG. 4

includes an opening layout of three FMMs: an FMM for R pixels, an FMM for G pixels, and an FMM for B pixels. The centroids of R pixels **251R**, G pixels **251G**, and B pixels **251B** are located at the same points as the centroids of FMM openings **541R**, **541G**, and **541B**, respectively, when seen in the stacking direction.

[0094] As understood from the foregoing description about the relation between the pixels and the FMM openings, the description about the pixels and pixel rows is applicable to the FMM openings and the rows of FMM openings. Each FMM, for example the FMM for R pixels, is provided with a plurality of FMM openings **541R** and the plurality of FMM openings **541** are disposed in a plurality of rows. The row direction of the FMM openings **541** is the X-axis direction.

[0095] Each row of FMM openings **541R** is composed of FMM openings **541R** disposed at regular distances. The pitch of the FMM openings **541R** corresponds to the distance between the centroids of FMM openings **541R** adjacent to each other in the row and is 3Px. Each FMM opening **541R** has an octagonal shape symmetric about a given line passing through its centroid and all FMM openings **541R** have the same shape. The centroids of the FMM openings **541R** in a row are located on a line extending in the X-axis direction.

[0096] In each FMM, for example in the FMM for R pixels, the rows of FMM openings **541R** are disposed in the column direction (Y-axis direction) at regular distances Py. In other words, the distances between lines passing through the centroids of the FMM openings in individual rows of FMM openings **541R** are the same Py. The layout of the FMM openings **541R** is a staggered arrangement.

[0097] Each row is different in position with respect to its adjacent rows by (3/2)Px. In each row, an FMM opening **541R** is located at the center between FMM openings **541R** adjacent to each other in each of the two adjacent rows. Specifically, the centroid of an FMM opening **541R** is located at the center between the centroids of FMM openings **541R** adjacent to each other in each of the two adjacent rows.

[0098] The FMM opening can be smaller than the anode electrode of the corresponding pixel. In actual manufacture, the centroids of the FMM openings positioned onto the substrate **151** for vapor deposition of an organic light-emitting material are not always located at the centroids of the pixels. The ratio of a pixel to the FMM opening therefor is determined depending on the margin required in the manufacturing process.

[0099] FIG. 5 illustrates a color pattern of the pixels in the delta-nabla arrangement for real resolution. A delta display pixel **255A** consists of an R pixel **251R**, a G pixel **251G**, and a B pixel **251B** and has a triangular (delta) shape in which the G pixel **251G** is located at the center. A nabla display pixel **255B** consists of an R pixel **251R**, a G pixel **251G**, and a B pixel **251B** and has an inverted-triangular (nabla) shape in which the G pixel **251G** is located at the center.

[0100] The display pixel pitch DPx in the row direction is equal to the display pixel pitch DPy in the column direction. Accordingly, the colors of R, G, and B are balanced in a square as indicated by the square **257** surrounded by a dashed line.

[0101] FIG. 6 illustrates a relation among the row direction display pixel pitch DPx, the column direction display pixel pitch DPy, the row direction pixel pitch Px, and the

column direction pixel pitch P_y in the pixel layout of the octagonal pixels illustrated in FIG. 4. The row direction pixel pitch P_x is $\frac{2}{3}$ of the row direction display pixel pitch DP_x .

[0102] The column direction pixel pitch P_y is $\frac{1}{2}$ of the column direction display pixel pitch Dpy (Dpx). The ratio of the row direction pixel pitch P_x to the column direction pixel pitch P_y is $\frac{4}{3}$ to 1. In the example of FIG. 6, the length W_x in the row direction of an FMM opening is equal to the row direction pixel pitch P_x . The length W_y in the column direction of an FMM opening is equal to the column direction pixel pitch P_y . The center between the centroids of pixels adjacent in the row direction and the center between the centroids of pixels adjacent in the column direction are located on the perimeter of an FMM opening.

[0103] FIG. 7 illustrates a layout of pixels of one of the colors of red, green, and blue, anode electrodes thereof, and FMM openings therefor. The following description applies to the pixel patterns of all colors of red, green and blue. FIG. 7 includes four sets of a pixel, an anode electrode, and an FMM opening, by way of example. In relation to the pixel 251J, the pixel 251K is an adjacent pixel of the same color in a pixel row adjacent to the row including the pixel 251J. The pixel 251K is a pixel of the same color as the pixel 251J and closest to the pixel 251J in a pixel row adjacent to the row including the pixel 251J.

[0104] The pixel 251J has four adjacent pixels of the same color in the pixel rows adjacent to the row including the pixel 251J. One of the four pixels is the pixel 251K; the relation between the pixel 251J and the pixel 251K described in the following applies to the relations between the pixel 251J and the three other pixels.

[0105] The distance between the pixel 251J and the pixel 251K is the distance between their centroids. The pixel 251J has a side 611J facing the pixel 251K. The pixel 251K has a side 611K facing the pixel 251J. The side 611J of the pixel 251J and the side 611K of the pixel 251K opposed to each other intersect with the line (the centroid connecting line) connecting the centroid of the pixel 251J and the centroid of the pixel 251K.

[0106] The distance between the perimeter of the pixel 251J and the perimeter of the pixel 251K is the distance between the sides 611J and 611K opposed to each other. In FIG. 7, the distance between the sides 611J and 611K opposed to each other is denoted by B1. FIG. 7 indicates the distance B1 between the pixel 251L and the pixel 251M for convenience of illustration. The relation between the pixel 251L and the pixel 251M is the same as the relation between the pixel 251J and the pixel 251K.

[0107] The line (the centroid connecting line) connecting the centroid of the pixel 251J and the centroid of the pixel 251K intersects perpendicularly (at 90.0 degrees) with the sides 611J and 611K opposed to each other. Accordingly, the distance between the point where the centroid connecting line intersects with the side 611J and the point where the centroid connecting line intersects with the side 611K is the distance B1 between the sides 611J and 611K.

[0108] The distance in the row direction (X-axis direction) between the centroid of the pixel 251J and the centroid of the pixel 251K is $1.5P_x$. The distance in the column direction (Y-axis direction) between the centroid of the pixel 251J and the centroid of the pixel 251K is P_y . As described above, the ratio of P_x to P_y in the real resolution is 4 to 3. The angle between the side 611J and the line (centroid connecting line)

connecting the centroid of the pixel 251J and the centroid of the pixel 251K is 90.0 degrees. Accordingly, the angle θ_1 between the side 611K and the row direction (the X-axis) is 63.4 degrees. The angle between the side 611J and the row direction (the X-axis) is also $\theta_1=63.4$ degrees.

[0109] The same explanation applies to the relation between the anode electrodes 162J and 162K and the relation between the FMM openings 541J and 541K. Specific description is provided about the FMM openings 541J and 541K. The FMM opening 541K is an FMM opening adjacent to the FMM opening 541J in a row adjacent to the row including the FMM opening 541J. The FMM opening 541K is an FMM opening closest to the FMM opening 541J in a row adjacent to the row including the FMM opening 541J.

[0110] The FMM opening 541J has four adjacent FMM openings in the pixel rows adjacent to the row including the FMM opening 541J. One of the four FMM openings is the FMM opening 541K; the relation between the FMM opening 541J and the FMM opening 541K described in the following applies to the relations between the FMM opening 541J and the three other FMM openings.

[0111] The distance between the FMM opening 541J and the FMM opening 541K is the distance between their centroids. The FMM opening 541J has a side 613J facing the FMM opening 541K. The FMM opening 541K has a side 613K facing the FMM opening 541J. The side 613J of the FMM opening 541J and the side 613K of the FMM opening 541K opposed to each other intersect with the line (the centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541K.

[0112] The distance between the perimeter of the FMM opening 541J and the perimeter of the FMM opening 541K is the distance between the sides 613J and 613K opposed to each other. In FIG. 7, the distance between the sides 613J and 613K opposed to each other is denoted by B2. FIG. 7 indicates the distance B2 between the FMM opening 541L and the FMM opening 541M for convenience of illustration. The relation between the FMM opening 541L and the FMM opening 541M is the same as the relation between the FMM opening 541J and the FMM opening 541K.

[0113] The line (the centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541K intersects perpendicularly (at 90.0 degrees) with the sides 613J and 613K opposed to each other. Accordingly, the distance between the point where the centroid connecting line intersects with the side 613J and the point where the centroid connecting line intersects with the side 613K is the distance B2 between the sides 613J and 613K.

[0114] The distance in the row direction (X-axis direction) between the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is $1.5P_x$. The distance in the column direction (Y-axis direction) between the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is P_y . The angle between the side 613J and the line (centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is 90.0 degrees. Accordingly, the angle θ_2 between the side 613K and the row direction (the X-axis) is 63.4 degrees. The angle between the side 613J and the row direction (the X-axis) is also $\theta_2=63.4$ degrees.

[0115] Next, the relation between the pixel 251J and the pixel 251L is described. In relation to the pixel 251J, the pixel 251L is an adjacent pixel of the same color in the column direction. The pixel 251L is a pixel of the same color as the pixel 251J and closest to the pixel 251J in the pixel row located at two rows away from the pixel row including the pixel 251J. The pixel 251J has two adjacent pixels of the same color in the column direction. One of the two pixels is the pixel 251L; the relation between the pixel 251J and the pixel 251L described in the following applies to the relation between the pixel 251J and the other pixel.

[0116] The distance between the pixel 251J and the pixel 251L is the distance between their centroids. The pixel 251J has a side 615J facing the pixel 251L. The pixel 251L has a side 615L facing the pixel 251J. The side 615J of the pixel 251J and the side 615L of the pixel 251L opposed to each other intersect with the line (centroid connecting line) connecting the centroid of the pixel 251J and the centroid of the pixel 251L. The sides 615J and 615L are parallel to the row direction (the X-axis).

[0117] The distance between the perimeter of the pixel 251J and the perimeter of the pixel 251L is the distance between the sides 615J and 615L opposed to each other. In FIG. 7, the distance between the sides 615J and 615L opposed to each other is denoted by C1. The line (centroid connecting line) connecting the centroid of the pixel 251J and the centroid of the pixel 251L is parallel to the column direction (the Y-axis). Accordingly, the centroid connecting line intersects perpendicularly (at 90.0 degrees) with the sides 615J and 615L opposed to each other. The distance between the point where the centroid connecting line intersects with the side 615J and the point where the centroid connecting line intersects with the side 615L is the distance C1 between the sides 615J and 615L.

[0118] The same explanation applies to the relation between the anode electrodes 162J and 162L and the relation between the FMM openings 541J and 541L. Specific description is provided about the FMM openings 541J and 541L. The FMM opening 541L is an FMM opening adjacent to the FMM opening 541J in the column direction. The FMM opening 541L is an FMM opening closest to the FMM opening 541J in the row located two rows away from the row including the FMM opening 541J. The FMM opening 541J has two adjacent FMM openings in the column direction. One of the two FMM openings is the FMM opening 541L; the relation between the FMM opening 541J and the FMM opening 541L described in the following applies to the relation between the FMM opening 541J and the other FMM opening.

[0119] The distance between the FMM opening 541J and the FMM opening 541L is the distance between their centroids. The FMM opening 541J has a side 617J facing the FMM opening 541L. The FMM opening 541L has a side 617L facing the FMM opening 541J. The side 617J of the FMM opening 541J and the side 617L of the FMM opening 541L opposed to each other intersect with the line (the centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541L. The sides 617J and 617L are parallel to the row direction (the X-axis).

[0120] The distance between the perimeter of the FMM opening 541J and the perimeter of the FMM opening 541L is the distance between the sides 617J and 617L opposed to each other. In FIG. 7, the distance between the sides 617J

and 617L opposed to each other is denoted by C2. The line (centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541L is parallel to the column direction (the Y-axis). Accordingly, the centroid connecting line intersects perpendicularly (at 90.0 degrees) with the sides 617J and 617L opposed to each other. The distance between the point where the centroid connecting line intersects with the side 617J and the point where the centroid connecting line intersects with the side 617L is the distance C2 between the sides 617J and 617L.

[0121] As a nature of human eyes, when polygonal (inclusive of circular) pixels emitting three primary colors of light are closely adjacent to one another, human eyes recognize the pixels as one pixel of full color where the three primary colors of the adjacent pixels are mixed. To attain the ideal mixture of three colors (to attain a natural image in which the pixels are indistinctive), it is preferable that the distribution of the pixels (light emitting regions) of the same color be symmetric about the centroid of each pixel and each pixel have a larger area. Accordingly, it is important that the shape of a pixel be symmetric about a given line passing through the centroid and the distance from the centroid to the end of the pixel be long.

[0122] Meanwhile, for highly precise vapor deposition of an organic light-emitting material with an FMM, deformation of the FMM in the vapor deposition needs to be minimum. To achieve small deformation of the FMM, it is important that the bridge width of the FMM be wide. The bridge width is a distance between peripheries of FMM openings adjacent to each other. In the example of FIG. 7, the distance B2 is a bridge width in an oblique direction and the distance C2 is a bridge width in the column direction (Y-axis direction). The oblique direction is an intermediate direction between the row direction (X-axis direction) and the column direction (Y-axis direction).

[0123] When the opposed sides of pixels of the same color adjacent to each other are perpendiculars to the line connecting the centroids of these pixels and further, the opposed sides of FMM openings adjacent to each other are perpendiculars to the line connecting the centroids of these FMM openings, the distance from the centroid of a pixel to the end (perimeter) of the pixel can be maximized while attaining a desired bridge width.

[0124] Among the pixels of the same color in the pixel layout of delta-nabla arrangement, pixels close to a given pixel are two pixels adjacent in the column direction and four pixels adjacent in the oblique directions out of the pixels adjacent to the given pixel, as illustrated in FIG. 7. In the example of FIG. 7, the pixel 251L is a pixel adjacent to the pixel 251J in the column direction and the pixels 251K and 251M are pixels adjacent to the pixel 251J in the oblique directions. The distance between pixels adjacent to each other in the row direction is longer than the distance between pixels adjacent to each other in the column direction or the distance between pixels adjacent to each other in an oblique direction.

[0125] Accordingly, to achieve a larger pixel area while satisfying the foregoing conditions in the pixel arrangement in FIG. 7, the shape of each pixel is to be a hexagon or an octagon and the sides facing the pixels of the same color adjacent in the column direction and the oblique directions are to be perpendicular to the centroid connecting lines between the pixel and the adjacent pixels of the same color.

The octagonal pixel shown in FIG. 7 satisfies these conditions. The hexagonal pixel that satisfies the foregoing conditions has two corners on the line passing through its centroid and extending in the row direction.

[0126] In similar, the shape of each FMM opening that satisfies the foregoing conditions is a hexagon or an octagon and the sides facing the FMM openings adjacent in the column direction and the oblique directions are perpendicular to the centroid connecting lines between the FMM opening and the adjacent FMM openings. The octagonal FMM opening shown in FIG. 7 satisfies these conditions. The hexagonal FMM opening that satisfies the foregoing conditions has two corners on the line passing through its centroid and extending in the row direction.

[0127] As described above, the shape and the layout of the pixels and the shape and the layout of the FMM openings described with reference to FIG. 7 achieve a shape of pixel that is large and symmetric about the centroid and a wider bridge width.

[0128] FIG. 8 provides examples of the shape of a pixel or an FMM opening. The shape 801 is an octagon having curved corners. The shape 803 is a hexagon having round corners. The shape of a pixel or an FMM opening can be a hexagon or an octagon having round corners like these examples. The same explanation is applicable to the shape of an anode electrode 162.

Pixel Control

[0129] FIG. 9 schematically illustrates an example of a layout of pixels (anode electrodes thereof) and lines and an example of connection of the pixels (anode electrodes thereof) and the lines in the same pixel layout as the one in FIG. 4. FIG. 9 is to provide an example; any other connection is applicable to this pixel layout.

[0130] FIG. 9 includes twelve pixels, three data lines Xam, Xbm, Xcm, four scanning lines Yn, Yn+1, Yn+2, Yn+3, and three power lines 811. The remaining of the display region 125 has the same configuration as the one in FIG. 9.

[0131] The scanning lines Yn, Yn+1, Yn+2, and Yn+3 are connected with n-th pixel row, (n+1)th pixel row, (n+2)th pixel row, and (n+3)th pixel row, respectively. The scanning lines Yn, Yn+1, Yn+2, and Yn+3 supply scanning signals to the connected pixel rows one after another. In response to the scanning signal supplied from a scanning line, all pixels in the connected pixel row are selected.

[0132] The data line Xam is connected with a pixel column in which R pixels and G pixels are disposed alternately. The data line Xbm is connected with a pixel column in which G pixels and B pixels are disposed alternately. The data line Xcm is connected with a pixel column in which B pixels and R pixels are disposed alternately. The data line Xam repeats output to an R pixel and output to a G pixel alternately. The data line Xbm repeats output to a G pixel and output to a B pixel alternately. The data line Xcm repeats output to a B pixel and output to an R pixel alternately.

[0133] The data lines Xam, Xbm, Xcm are disposed alternately with the power lines 811. In the example of FIG. 9, each power line 811 supplies power to pixels through driving transistors each connected with one adjacent data line (for example, the data line on the left). The same connection of the data lines Xam, Xbm, and Xcm with pixels is repeated in the remaining of the display region 125.

[0134] FIG. 10 is a timing chart for driving the pixels in the pixel layout in FIG. 9. FIG. 10 provides waveforms of data signals (hereinafter, referred to as signals) from the data lines Xam, Xbm, and Xcm and waveforms of selection pulses from the scanning lines Yn, Yn+1, Yn+2, and Yn+3. The scanning lines Yn, Yn+1, Yn+2, and Yn+3 output selection pulses in turn at different times. The selection pulses for the scanning lines Yn, Yn+1, Yn+2, and Yn+3 are output by a scanning driver circuit 131. The data signals for the data lines Xam, Xbm, and Xcm are output by a driver IC 134.

[0135] When the scanning line Yn is outputting a selection pulse, the data line Xam outputs a signal to the R pixel in the n-th pixel row. When the scanning line Yn is outputting a selection pulse, the data line Xbm outputs a signal to the G pixel in the n-th pixel row. When the scanning line Yn is outputting a selection pulse, the data line Xcm outputs a signal to the B pixel in the n-th pixel row.

[0136] When the scanning line Yn+1 is outputting a selection pulse, the data line Xam outputs a signal to the G pixel in the (n+1)th pixel row. When the scanning line Yn+1 is outputting a selection pulse, the data line Xbm outputs a signal to the B pixel in the (n+1)th pixel row. When the scanning line Yn+1 is outputting a selection pulse, the data line Xcm outputs a signal to the R pixel in the (n+1)th pixel row.

[0137] When the scanning line Yn+2 is outputting a selection pulse, the data line Xam outputs a signal to the R pixel in the (n+2)th pixel row. When the scanning line Yn+2 is outputting a selection pulse, the data line Xbm outputs a signal to the G pixel in the (n+2)th pixel row. When the scanning line Yn+2 is outputting a selection pulse, the data line Xcm outputs a signal to the B pixel in the (n+2)th pixel row.

[0138] When the scanning line Yn+3 is outputting a selection pulse, the data line Xam outputs a signal to the G pixel in the (n+3)th pixel row. When the scanning line Yn+3 is outputting a selection pulse, the data line Xbm outputs a signal to the B pixel in the (n+3)th pixel row. When the scanning line Yn+3 is outputting a selection pulse, the data line Xcm outputs a signal to the R pixel in the (n+3)th pixel row.

[0139] The scanning lines Yn and Yn+1 successively output selection pulses within one horizontal period (1H). The scanning lines Yn+2 and Yn+3 successively output selection pulses within the next horizontal period (1H). The widths of the selection pulses are the same; each of the scanning lines Yn, Yn+1, Yn+2, and Yn+3 outputs a selection pulse in substantially $\frac{1}{2}$ of a horizontal period.

FMM Opening Layout

[0140] Hereinafter, the relation between the opening width and the bridge width in an FMM is described. FIG. 11 illustrates an FMM opening layout of an FMM for one of the colors of red, green and blue. The following description applies to the FMMs for all colors of red, green, and blue. The description provided with reference to FIG. 7 applies to FIG. 11.

[0141] The width in the column direction of an FMM opening is expressed as 2r1. The width in an oblique direction of an FMM opening is expressed as 2r2. The oblique direction is the direction connecting the centroid of

an FMM opening to the centroid of an adjacent FMM opening in a row adjacent to the row including the FMM opening.

[0142] To achieve small deformation of the FMM, it is preferable that the bridge width B2 be equal to or wider than the narrowest width A of an FMM opening. Furthermore, it is preferable that the bridge width C2 be equal to or wider than the narrowest width A. In the example of FIG. 11, the narrowest width A of an FMM opening is $2r1$. In the vapor deposition step in this embodiment, the FMM is positioned in the state where the FMM is pulled in the row direction. The relation between the bridge width B2 including components of the direction of pull and the narrowest width A of an FMM opening is more important.

[0143] In the FMM opening layout in FIG. 11, the bridge width C2 in the column direction is $(2Py-2r1)$, where Py is an FMM opening pitch (pixel pitch) in the column direction. The bridge width B2 in the oblique direction is $(Py/5-2r2)$.

[0144] To prevent deformation of the FMM, it is preferable to satisfy the following condition:

$$\text{Bridge width } B2 = (Py/5 - 2r2) \geq \text{Narrowest width } A \text{ of FMM opening} = 2r1.$$

[0145] To prevent deformation of the FMM, it is preferable to further satisfy the following condition:

$$\text{Bridge width } C2 = (2Py - 2r1) \geq \text{Narrowest width } A \text{ of FMM opening} = 2r1.$$

[0146] FIG. 12 illustrates another example of an FMM opening layout of an FMM for one of the colors of red, green, and blue. The following description applies to the FMMs for all colors of red, green, and blue. Each FMM opening is a true circle. The disposition of the centroids of the FMM openings (centers of the true circles) is the same as that in the layout in FIG. 11.

[0147] The radius of a circular FMM opening is expressed as r . As described with reference to FIG. 11, to prevent deformation of the FMM, it is preferable to satisfy the following condition:

$$\text{Bridge width } B2 = (Py/5 - 2r) \geq \text{Narrowest width } A \text{ of FMM opening} = 2r.$$

To prevent deformation of the FMM, it is preferable to further satisfy the following condition:

$$\text{Bridge width } C2 = (2Py - 2r) \geq \text{Narrowest width } A \text{ of FMM opening} = 2r.$$

[0148] The foregoing description is applicable to the layout of the pixels of the same color and the layout of the anode electrodes of the pixels of the same color. As described above, the disposition of the centroids of the pixels of the same color is the same as the disposition of the centroids of the FMM openings and the shape of the pixels is smaller than and similar to the shape of the FMM openings. Accordingly, it is preferable that the distance B1 between the perimeters of the pixels of the same color adjacent to each other in an oblique direction or the distance C1 between the perimeters of the pixels of the same color adjacent to each other in the column direction be equal to or longer than the narrowest pixel width. The same applies to the anode electrodes.

Another Layout of Pixels and FMM Openings

[0149] FIG. 13 illustrates a pixel layout of delta-nabla arrangement for displaying an image by rendering, specifi-

cally, a pixel layout for delta-nabla vertical direction $\frac{2}{3}$ pixel rendering. The number of pixel columns (data lines) is the same as that in the pixel layout for the real resolution and the number of pixel rows (scanning lines) is $\frac{2}{3}$ of that in the pixel layout for the real resolution. This configuration facilitates designing the TFT circuit. This configuration allows reduction in number of output pins of the scanning driver 131 and the emission driver 132; accordingly, the TFT circuit can be designed easily and the area occupied by the drivers is reduced.

[0150] Like FIG. 4, FIG. 13 illustrates a layout of pixels, anode electrodes, and FMM openings of three FMMs. In the following, differences from the delta-nabla arrangement for the real resolution described with reference to FIGS. 4 to 6 are mainly described.

[0151] Compared to the layout for the real resolution in FIG. 4, this layout is different in the ratio of the pixel pitch Px in the row direction to the pixel pitch Py in the column direction. Furthermore, the aspect ratios of the pixels, the anode electrodes, and the FMM openings are different. The vertical direction corresponds to the column direction and the horizontal direction corresponds to the row direction.

[0152] FIG. 14 illustrates a color pattern of the pixels for the delta-nabla vertical direction $\frac{2}{3}$ pixel rendering. As indicated by the rectangle 258 surrounded by a dashed line, the colors of R, G, and B are balanced in a rectangle having an aspect ratio of 3 to 2. The definition of a display pixel for rendering is ambiguous, unlike the display pixel for the real resolution.

[0153] The ratio of the pixel pitch Px in the row direction to the pixel pitch Py in the column direction is 8 to 9. Like the pixel layout for the real resolution, the length Wx in the row direction of an FMM opening is equal to the pixel pitch Px in the row direction. Furthermore, the length Wy in the column direction of an FMM opening is equal to the pixel pitch Py in the column direction.

[0154] FIG. 15 illustrates a layout of pixels of one of the colors of red, green, and blue, anode electrodes thereof, and FMM openings therefor for the delta-nabla vertical direction $\frac{2}{3}$ pixel rendering. The following description applies to the pixel patterns of all colors of red, green and blue. In the following, differences from the layout for the real resolution described with reference to FIG. 7 are mainly described.

[0155] Like the layout for the real resolution, the line (the centroid connecting line) connecting the centroid of the pixel 251J and the centroid of the pixel 251K intersects perpendicularly (at 90.0 degrees) with the sides 611J and 611K opposed to each other. As described above, the ratio of the pixel pitch Px in the row direction to the pixel pitch Py in the column direction is 8 to 9, unlike the layout for the real resolution. Accordingly, the angle $\theta 1$ between the side 611K and the row direction (the X-axis) is 53.1 degrees. The angle between the side 611J and the row direction (the X-axis) is also $\theta 1 = 53.1$ degrees.

[0156] Like the layout for the real resolution, the line (the centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541K intersects perpendicularly (at 90.0 degrees) with the sides 613J and 613K opposed to each other.

[0157] The distance in the row direction (X-axis direction) between the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is $1.5Px$. The distance

in the column direction (Y-axis direction) between the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is Py.

[0158] Furthermore, the angle between the side 613J and the line (centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is 90.0 degrees. Accordingly, the angle θ_2 between the side 613K and the row direction (the X-axis) is 53.1 degrees. The angle between the side 613J and the row direction (the X-axis) is also $\theta_2=53.1$ degrees.

[0159] The description provided with reference to FIG. 11 or 12 is applicable to the FMM opening layout for the delta-nabla vertical direction $\frac{2}{3}$ pixel rendering. In the FMM opening layout for the delta-nabla vertical direction $\frac{2}{3}$ pixel rendering, the bridge width C2 in the column direction is $(2Py-2r1)$. The bridge width B2 in the oblique direction is $(5Py/3-2r2)$. As illustrated in FIG. 15, in a right triangle having the hypotenuse of the centroid connecting line between two pixels, the relation among the base, the short side (height), and the hypotenuse is 4 (indicated as 2 in FIG. 15): 3 (indicated as 1.5 in FIG. 15): 5 and a half of the width of an opening in the direction along the centroid connecting line is r2 (see FIG. 11); accordingly the bridge width B2 in the oblique direction can be expressed as above.

[0160] Accordingly, to prevent deformation of the FMM, it is preferable that the layout of hexagonal or octagonal FMM openings satisfy the following condition;

$$\text{Bridge width } B2=(5Py/3-2r2) \geq \text{Narrowest width } A \text{ of FMM opening}=2r1.$$

[0161] To prevent deformation of the FMM, it is preferable to further satisfy the following condition:

$$\text{Bridge width } C2=(2Py-2r1) \geq \text{Narrowest width } A \text{ of FMM opening}=2r1.$$

[0162] As to the layout of true circular FMM openings, it is preferable to satisfy the following condition:

$$\text{Bridge width } B2=(5Py/3-2r) \geq \text{Narrowest width } A \text{ of FMM opening}=2r.$$

[0163] To prevent the deformation of the FMM, it is preferable to further satisfy the following condition:

$$\text{Bridge width } C2=(2Py-2r) \geq \text{Narrowest width } A \text{ of FMM opening}=2r.$$

[0164] The foregoing description is applicable to the layout of the pixels of the same color and the layout of the anode electrodes of the pixels of the same color. As described above, the disposition of the centroids of the pixels of the same color is the same as the disposition of the centroids of the FMM openings and the shape of the pixels is smaller than and similar to the shape of the FMM openings. Accordingly, it is preferable that the distance B1 between the perimeters of the pixels of the same color adjacent to each other in an oblique direction or the distance C1 between the perimeters of the pixels of the same color adjacent to each other in the column direction be equal to or longer than the narrowest pixel width. The same applies to the anode electrodes.

Still Another Layout of Pixels and FMM Openings

[0165] FIG. 16 illustrates another pixel layout of delta-nabla arrangement for displaying an image by rendering, specifically, a pixel layout for delta-nabla horizontal direction $\frac{2}{3}$ pixel rendering. The number of pixel rows (scanning

lines) is the same as that in the pixel layout for the real resolution and the number of pixel columns (data lines) is $\frac{2}{3}$ of that in the pixel layout for the real resolution. This configuration allows reduction in number of output pins of the data driver IC.

[0166] Like FIG. 4, FIG. 16 illustrates a layout of pixels, anode electrodes, and FMM openings of three FMMs. In the following, differences from the delta-nabla arrangement for the real resolution described with reference to FIGS. 4 to 6 are mainly described.

[0167] Compared to the layout for the real resolution in FIG. 4, this layout is different in the ratio of the pixel pitch Px in the row direction to the pixel pitch Py in the column direction. Furthermore, the aspect ratios of the pixels, the anode electrodes, and the FMM openings are different. The vertical direction corresponds to the column direction and the horizontal direction corresponds to the row direction.

[0168] FIG. 17 illustrates a color pattern of the pixels for the delta-nabla horizontal direction $\frac{2}{3}$ pixel rendering. As indicated by the rectangle 259 surrounded by a dashed line, the colors of R, G, and B are balanced in a rectangle having an aspect ratio of 2 to 3. The definition of a display pixel for rendering is ambiguous, unlike the display pixel for the real resolution.

[0169] The ratio of the pixel pitch Px in the row direction to the pixel pitch Py in the column direction is 2 to 1. Like the pixel layout for the real resolution, the length Wx in the row direction of an FMM opening is equal to the pixel pitch Px in the row direction. Furthermore, the length Wy in the column direction of an FMM opening is equal to the pixel pitch Py in the column direction.

[0170] FIG. 18 illustrates a layout of pixels of one of the colors of red, green, and blue, anode electrodes thereof, and FMM openings therefor for the delta-nabla horizontal direction $\frac{2}{3}$ pixel rendering. The following description applies to the pixel patterns of all colors of red, green and blue. In the following, differences from the layout for the real resolution described with reference to FIG. 7 are mainly described.

[0171] Like the layout for the real resolution, the line (the centroid connecting line) connecting the centroid of the pixel 251J and the centroid of the pixel 251K intersects perpendicularly (at 90.0 degrees) with the sides 611J and 611K opposed to each other. As described above, the ratio of the pixel pitch Px in the row direction to the pixel pitch Py in the column direction is 2 to 1, unlike the layout for the real resolution. Accordingly, the angle θ_1 between the side 611K and the row direction (the X-axis) is 71.6 degrees. The angle between the side 611J and the row direction (the X-axis) is also $\theta_1=71.6$ degrees.

[0172] Like the layout for the real resolution, the line (the centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541K intersects perpendicularly (at 90.0 degrees) with the sides 613J and 613K opposed to each other.

[0173] The distance in the row direction (X-axis direction) between the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is 1.5Px. The distance in the column direction (Y-axis direction) between the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is Py.

[0174] Furthermore, the angle between the side 613J and the line (centroid connecting line) connecting the centroid of the FMM opening 541J and the centroid of the FMM opening 541K is 90.0 degrees. Accordingly, the angle θ_2

between the side 613K and the row direction (the X-axis) is 71.6 degrees. The angle between the side 613J and the row direction (the X-axis) is also $\theta_2=71.6$ degrees.

[0175] The description provided with reference to FIG. 11 or 12 is applicable to the FMM opening layout for the delta-nabla horizontal direction $\frac{2}{3}$ pixel rendering. In the FMM opening layout for the delta-nabla horizontal direction $\frac{2}{3}$ pixel rendering, the bridge width C2 in the column direction is $(2Py-2r1)$. The bridge width B2 in the oblique direction is $(Py\sqrt{10}-2r2)$. As illustrated in FIG. 18, in a right triangle having the hypotenuse of the centroid connecting line between two pixels, the relation among the base, the short side (height), and the hypotenuse is 3 (indicated as 3 in FIG. 18): 1 (indicated as 1 in FIG. 18): $\sqrt{10}$, and a half of the width of an opening in the direction along the centroid connecting line is r2 (see FIG. 11); accordingly the bridge width B2 in the oblique direction can be expressed as above.

[0176] Accordingly, to prevent deformation of the FMM, it is preferable that the layout of hexagonal or octagonal FMM openings satisfy the following condition;

$$\text{Bridge width } B2=(Py\sqrt{10}-2r2)\geq\text{Narrowest width } A \text{ of FMM opening}=2r1.$$

[0177] To prevent deformation of the FMM, it is preferable to further satisfy the following condition:

$$\text{Bridge width } C2=(2Py-2r1)\geq\text{Narrowest width } A \text{ of FMM opening}=2r1.$$

[0178] As to the layout of true circular FMM openings, it is preferable to satisfy the following condition:

$$\text{Bridge width } B2=(Py\sqrt{10}-2r)\geq\text{Narrowest width } A \text{ of FMM opening}=2r.$$

[0179] To prevent deformation of the FMM, it is preferable to further satisfy the following condition:

$$\text{Bridge width } C2=(2Py-2r)\geq\text{Narrowest width } A \text{ of FMM opening}=2r.$$

[0180] The foregoing description is applicable to the layout of the pixels of the same color and the layout of the anode electrodes of the pixels of the same color. As described above, the disposition of the centroids of the pixels of the same color is the same as the disposition of the centroids of the FMM openings and the shape of the pixels is smaller than and similar to the shape of the FMM openings. Accordingly, it is preferable that the distance B1 between the perimeters of the pixels of the same color adjacent to each other in an oblique direction or the distance C1 between the perimeters of the pixels of the same color adjacent to each other in the column direction be equal to or longer than the narrowest pixel width. The same applies to the anode electrodes.

[0181] As set forth above, embodiments of this invention have been described; however, this invention is not limited to the foregoing embodiments. Those skilled in the art can easily modify, add, or convert each element in the foregoing embodiment within the scope of this invention. A part of the configuration of one embodiment can be replaced with a configuration of another embodiment or a configuration of an embodiment can be incorporated into a configuration of another embodiment. For the angle θ , 63.4 degrees, 53.1 degrees, and 71.6 degrees are exemplified: the angle may be in a certain range because of the manufacturing step or the manufacturing conditions.

APPENDIX

[0182] Hereinafter, some features of this disclosure are provided as supplemental.

[0183] (1) A mask to be used in vapor deposition of an organic light-emitting material onto a substrate, the mask having a plurality of openings,

[0184] wherein the plurality of openings are provided in a plurality of rows,

[0185] wherein the openings in each of the plurality of rows are disposed at regular distances,

[0186] wherein the plurality of openings have the same shape that is symmetric about a given line passing through the centroid thereof,

[0187] wherein the centroids of the openings in each of the plurality of rows are located on a line extending in a first direction,

[0188] wherein distances between lines passing through the centroids of the openings in each of the plurality of rows are uniform,

[0189] wherein, in each pair consisting of two rows adjacent to each other in the plurality of rows, each of the openings in one of the two rows is located at the center between openings in the other row,

[0190] wherein the shortest distance between a perimeter of a first opening in one of the plurality of rows and a perimeter of a second opening that is closest to the first opening in a row adjacent to the row including the first opening is a distance B2 between a point where a centroid connecting line connecting the centroid of the first opening and the centroid of the second opening intersects with the perimeter of the first opening and a point where the centroid connecting line intersects with the perimeter of the second opening, and

[0191] wherein the distance B2 is equal to or longer than the narrowest width of the first opening.

[0192] (2) The mask according to the foregoing (1),

[0193] wherein the shortest distance between a perimeter of the first opening and a perimeter of a third opening that is adjacent to the first opening in a second direction perpendicular to the first direction is a distance C2 between a point where a centroid connecting line connecting the centroid of the first opening and the centroid of the third opening intersects with a side of the first opening and a point where the centroid connecting line intersects with a side of the third opening facing the side of the first opening, and

[0194] wherein the distance C2 is equal to or longer than the narrowest width of the first opening.

[0195] (3) The mask according to the foregoing (1),

[0196] wherein each opening has a true circular shape, and

[0197] wherein the following relation is satisfied:

$$4r\leq p\sqrt{5},$$

[0198] where r represents the radius of the true circle and p represents the distance between rows of openings and $\frac{1}{4}$ of the distance between openings in a row.

[0199] (4) The mask according to the foregoing (3), wherein the following relation is further satisfied:

$$2r\leq p.$$

[0200] (5) The mask according to the foregoing (1),
 [0201] wherein each opening has an octagonal or hexagonal shape having two sides parallel to the first direction, and

[0202] wherein the following relation is satisfied:

$$2(r1+r2) \leq p\sqrt{5},$$

[0203] where r1 represents a half of the width in the second direction of the opening, r2 represents a half of the width of the opening in the direction along the centroid connection line, and p represents the distance between rows of openings and $\frac{1}{4}$ of the distance between openings in a row.

[0204] (6) The mask according to the foregoing (5), wherein the following relation is further satisfied:

$$2r1 \leq p.$$

[0205] (7) The mask according to the foregoing (1),

[0206] wherein each opening has a true circular shape, and

[0207] wherein the following relation is satisfied:

$$4r \leq 5p/2,$$

[0208] where r represents the radius of the true circle, and p represents the distance between rows of openings and $\frac{3}{8}$ of the distance between openings in a row.

[0209] (8) The mask according to the foregoing (7), wherein the following relation is further satisfied:

$$4r \leq 3p.$$

[0210] (9) The mask according to the foregoing (1),

[0211] wherein each opening has an octagonal or hexagonal shape including two sides parallel to the first direction, and

[0212] wherein the following relation is satisfied:

$$2(r1+r2) \leq 5p/2,$$

[0213] where r1 represents a half of the width in the second direction of an opening, r2 represents a half of the width of the opening in the direction along the centroid connecting line, and p represents the distance between rows of openings and $\frac{3}{8}$ of the distance between openings in a row.

[0214] (10) The mask according to the foregoing (9), wherein the following relation is further satisfied:

$$4r1 \leq 3p.$$

What is claimed is:

1. An OLED display device comprising:

a plurality of pixels of a first color;

a plurality of pixels of a second color; and

a plurality of pixels of a third color,

wherein the plurality of pixels of the first color, the plurality of pixels of the second color, and the plurality of pixels of the third color are provided in a plurality of pixel rows,

wherein each of the plurality of pixel rows includes pixels disposed cyclically in order of the first color, the second color, and the third color at regular distances,

wherein the plurality of pixels of the first color, the plurality of pixels of the second color, and the plurality of pixels of the third color have the same polygonal shape that is symmetric about a line passing through the centroid thereof,

wherein the centroids of the pixels in each of the plurality of pixel rows are located on a line extending in a first direction,

wherein distances between lines passing through the centroids of the pixels in each of the plurality of pixel rows are uniform,

wherein, in each pair consisting of two pixel rows adjacent to each other in the plurality of pixel rows, each of the pixels of the first color in a first pixel row of the pair of the two pixel rows is located at the center in the first direction between pixels of the first color adjacent to each other in a second pixel row of the pair of the two pixel rows,

wherein the shortest distance between a perimeter of a first pixel of each of the first color, the second color, and the third color and a perimeter of a second pixel of the same color as the first pixel that is closest to the first pixel in a pixel row adjacent to the pixel row including the first pixel is a distance between a first point and a second point, the first point being where a centroid connecting line connecting the centroid of the first pixel and the centroid of the second pixel intersects with a side of the first pixel opposed to a side of the second pixel, the second point where the centroid connecting line intersects with the side of the second pixel opposed to the side of the first pixel, and

wherein the side of the first pixel and the side of the second pixel opposed to each other are perpendicular to the centroid connecting line.

2. The OLED display device according to claim 1, wherein an angle between the first direction and each of the sides opposed to each other is one of 63.4 degrees, 53.1 degrees, and 71.6 degrees.

3. The OLED display device according to claim 1, wherein the polygonal shape is an octagon or a hexagon including two sides parallel to the first direction.

4. The OLED display device according to claim 1,

wherein lower electrodes of the pixels in the plurality of pixel rows have a shape larger than and similar to the polygonal shape, and

wherein the centroids of the pixels in the plurality of pixel rows are located at the same points as the centroids of the lower electrodes of the pixels when seen in a stacking direction.

5. A mask to be used in vapor deposition of an organic light-emitting material onto a substrate in manufacturing an OLED display device, the mask having a plurality of openings,

wherein the plurality of openings are provided in a plurality of rows,

wherein the openings in each of the plurality of rows are disposed at regular distances,

wherein the plurality of openings have the same polygonal shape that is symmetric about a given line passing through the centroid thereof,

wherein the centroids of the openings in each of the plurality of rows are located on a line extending in a first direction,

wherein distances between lines passing through the centroids of the openings in each of the plurality of rows are uniform,

wherein, in each pair consisting of two rows adjacent to each other in the plurality of rows, each of the openings

in a first row of the two rows is located at the center between openings adjacent to each other in a second row of the two rows,

wherein the shortest distance between a perimeter of a first opening in one of the plurality of rows and a perimeter of a second opening that is closest to the first opening in a row adjacent to the row including the first opening is a distance B2 between a point where a centroid connecting line connecting the centroid of the first opening and the centroid of the second opening intersects with a side of the first opening opposed to a side of the second opening and a point where the centroid connecting line intersects the side of the second opening opposed to the side of the first opening, and

wherein an angle between the first direction and each of the sides opposed to each other is one of 63.4 degrees, 53.1 degrees, or 71.6 degrees.

6. The mask according to claim 5, wherein the polygonal shape is an octagon or a hexagon including two sides parallel to the first direction.

7. The mask according to claim 5, wherein the distance B2 is equal to or longer than the narrowest width of the first opening.

8. The mask according to claim 7,

wherein the shortest distance between a perimeter of the first opening and a perimeter of a third opening that is adjacent to the first opening in a second direction perpendicular to the first direction is a distance C2 between a point where a centroid connecting line connecting the centroid of the first opening and the centroid of the third opening intersects with a side of the first opening opposed to a side of the third opening and a point where the centroid connecting line intersects with the side of the third opening opposed to the side of the first opening, and

wherein the distance C2 is equal to or longer than the narrowest width of the first opening.

9. The mask according to claim 7, wherein the mask is positioned to the substrate in a state where the mask is pulled in the first direction in the vapor deposition.

10. A method of manufacturing an OLED display device, comprising:

a step of vapor-depositing an organic light-emitting material onto a substrate through a mask,

wherein the mask has a plurality of openings,

wherein the plurality of openings are provided in a plurality of rows,

wherein the openings in each of the plurality of rows are disposed at regular distances,

wherein the plurality of openings have the same polygonal shape that is symmetric about a given line passing through the centroid thereof,

wherein the centroids of the openings in each of the plurality of rows are located on a line extending in a first direction,

wherein distances between lines passing through the centroids of the openings in each of the plurality of rows are uniform,

wherein, in each pair consisting of two rows adjacent to each other in the plurality of rows, each of the openings in one of the two rows is located at the center between openings in the other row,

wherein the shortest distance between a perimeter of a first opening in one of the plurality of rows and a perimeter of a second opening that is closest to the first opening in a row adjacent to the row including the first opening is a distance B2 between a point where a centroid connecting line connecting the centroid of the first opening and the centroid of the second opening intersects with a side of the first opening opposed to a side of the second opening and a point where the centroid connecting line intersects the side of the second opening opposed to the side of the first opening, and

wherein an angle between the first direction and each of the sides opposed to each other is 63.4 degrees, 53.1 degrees, or 71.6 degrees.

11. The method according to claim 10, wherein the polygonal shape is an octagon or a hexagon including two sides parallel to the first direction.

12. The method according to claim 10, wherein the distance B2 is equal to or longer than the narrowest width of the first opening.

13. The method according to claim 12,

wherein the shortest distance between a perimeter of the first opening and a perimeter of a third opening that is adjacent to the first opening in a second direction perpendicular to the first direction is a distance C2 between a point where a centroid connecting line connecting the centroid of the first opening and the centroid of the third opening intersects with a side of the first opening opposed to a side of the third opening and a point where the centroid connecting line intersects with the side of the third opening opposed to the side of the first opening, and

wherein the distance C2 is equal to or longer than the narrowest width of the first opening.

14. The method according to claim 12, wherein the mask is positioned to the substrate in a state where the mask is pulled in the first direction in the vapor deposition.

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摘要(译)

穿过每个像素行中的像素的质心的线之间的距离是均匀的。在由两个相邻像素行组成的每对中，所述两个像素行对中的第一像素行中的第一颜色的每个像素位于第一颜色的彼此相邻的第一颜色的像素之间的第一方向上的中心处两个像素行对的像素行。第一像素的周长与相邻像素行中最靠近第一像素的相同颜色的第二像素之间的最短距离是连接第一像素的质心的线与该第一像素的质心的点之间的距离。第二像素与第一像素和第二像素的相对侧相交。

